

Probing Electronic Properties of Two-Dimensional Materials with a Planar Tunnel Junction

2017. 11. 15

Suyong Jung

Quantum Technology Institute



KRISS 한국표준과학연구원

KRISS 현황

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한국표준과학연구원

헌법

제127조 제2항
“국가는 국가표준제도를 확립한다”

국가표준
기본법

제13조 (국가 측정표준 대표기관)
“한국표준과학연구원을 국가측정표준 대표기관으로 한다”



국가는 국가표준제도를 확립한다

헌법 제127조 제2항

국가
측정표준
확립 및
유지향상

“편리하고 안전한 사회를 위한 기준,
국가측정표준 확립”

측정과학
기술
연구개발

“국가 산업경쟁력을 선도하는 측정기술 연구”

측정표준
측정과학기술
보급 및
서비스

“산업체의 측정능력 향상을 뒷받침하는
믿을 수 있는 지원자”

- 교정/시험/인증표준물질(CRM) 개발 및 보급
- 산업체 측정 전문인력 교육

세계
측정표준
선도기관

측정과학
기술적시
공급

산업협력
지원중심
기관



■ 1975.12 **국가표준기관으로
한국표준연구소설립**



■ 1999.2 “국가표준기본법”에
국가측정표준
대표기관으로 명문화

■ 2004.10 과학기술부
공공기술연구회
소관기관으로 변경



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Since 1975

■ 2015.
**한국표준과학연구원
창립 40주년**

■ 1978.3 대덕연구단지
내현 위치 입주



■ 1991.10 “한국표준과학연구원”으로
기관명칭 변경(천문대 및
기초과학지원연구센터 통합)

■ 2014.6
미래창조과학부
국가과학기술연구회
소관기관으로 변경

■ 2017.7
**과학기술정보통신부
국가과학기술연구회
소관기관으로 변경**



과학기술정보통신부

Ministry of Science and ICT



국가과학기술연구회

National Research Council of Science & Technology

(25 개 정부출연연구기관)



한국표준과학연구원

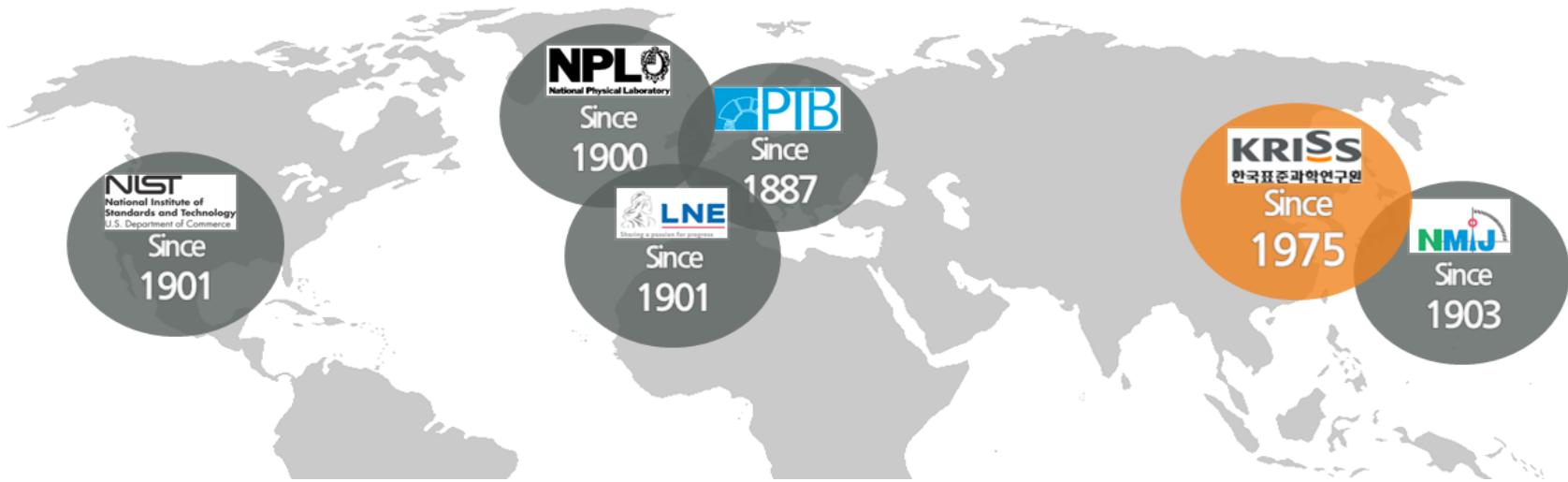
Korea Research Institute of Standards and Science



ET

한국물리연구원 ?

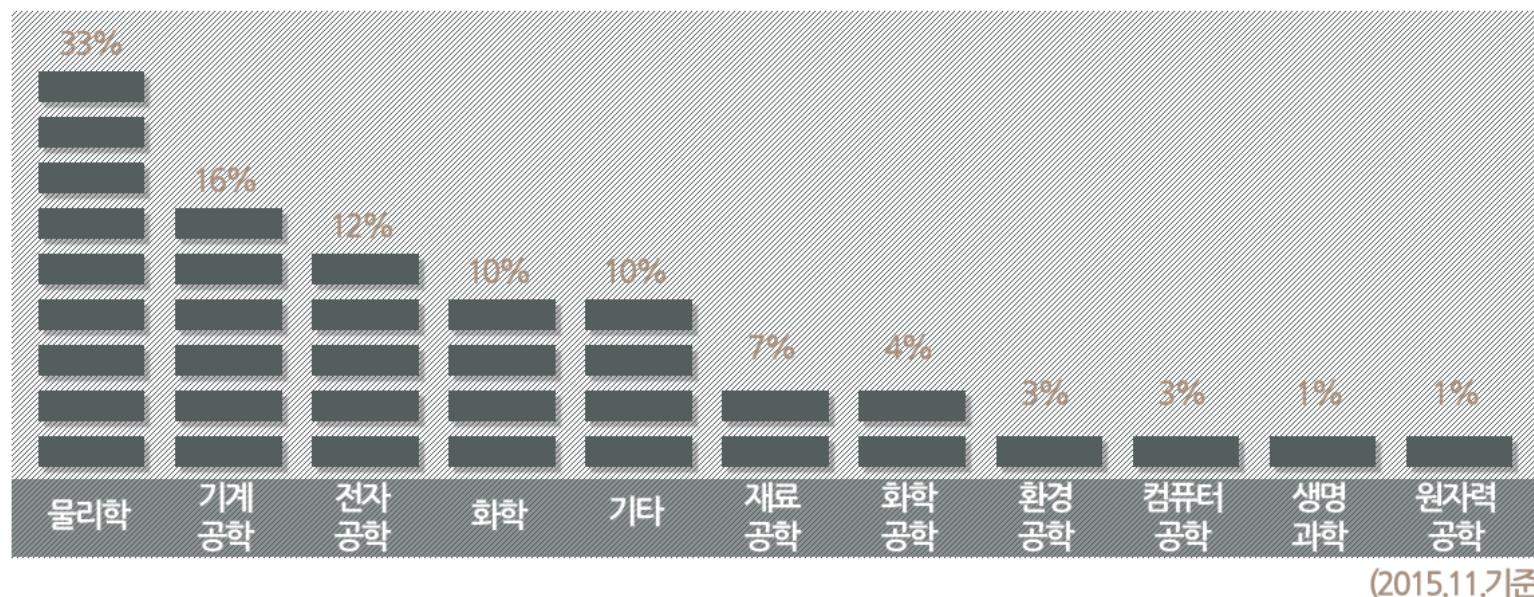
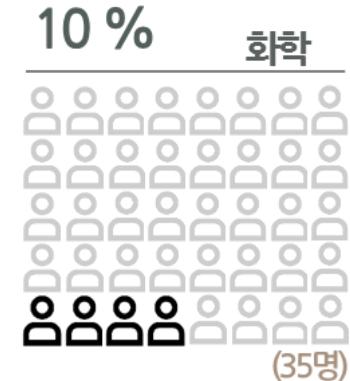
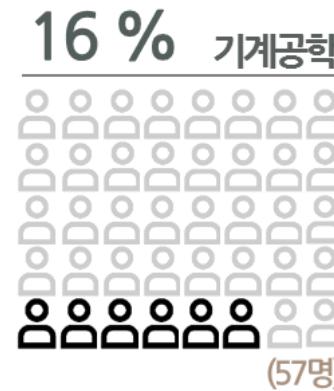
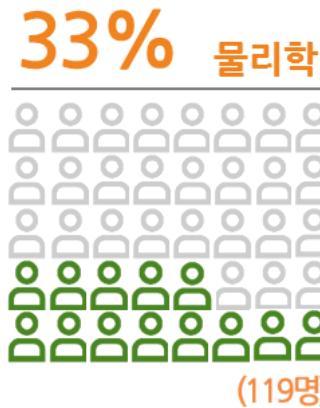




- (미국) National Institute of Standards and Technology (NIST) : four Nobel physics prizes
- (영국) National Physical Laboratory (NPL)
- (독일) Physikalisch-Technische Bundesanstalt (PTB)
- (프랑스) Laboratoire national de métrologie et d'essais (LNE)
- (일본) National Metrology Institute of Japan (NMJJ)

정규직원 전공별 분포 (연구·기술직)

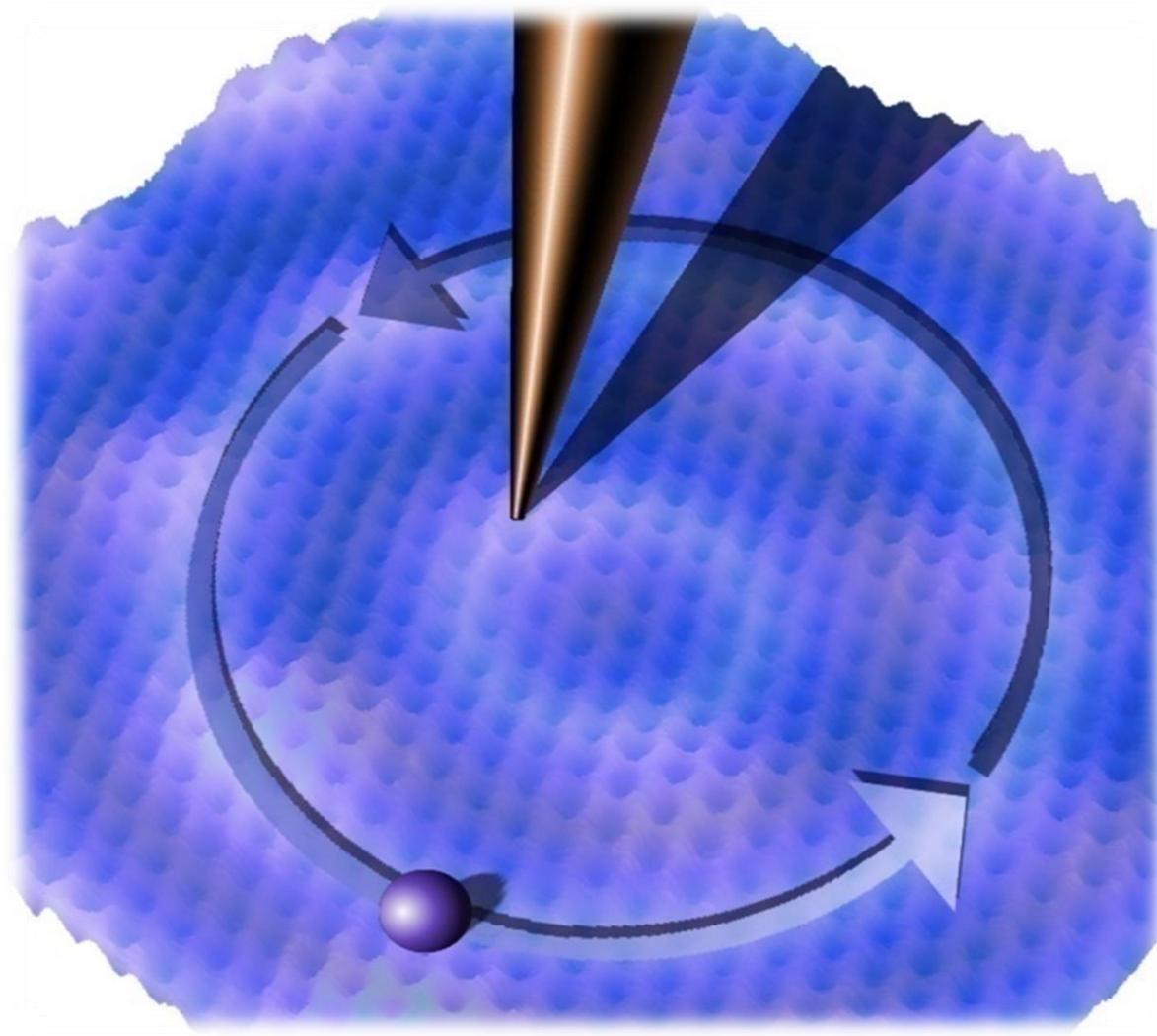
III. Better Standards, KRISS

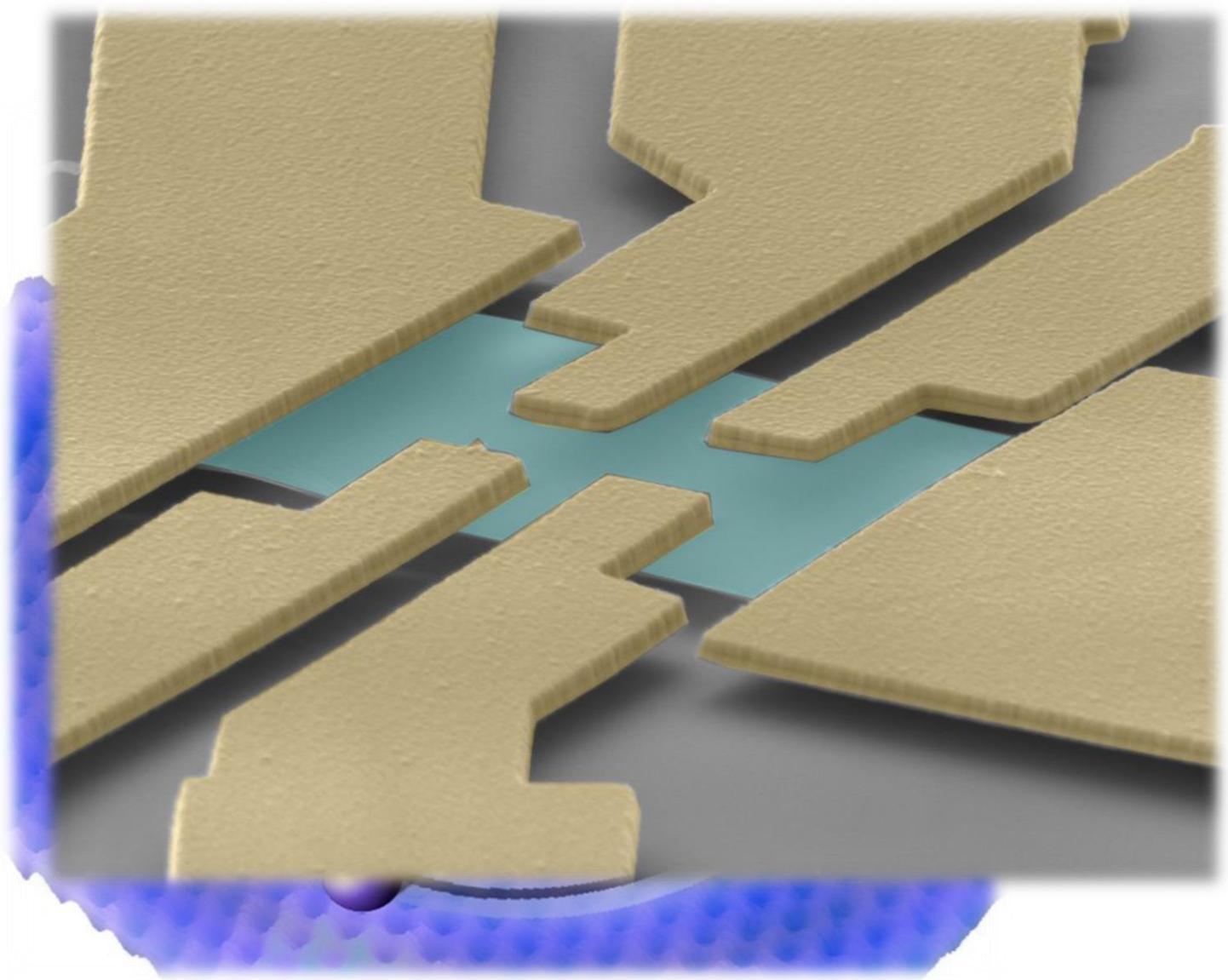




KRISS 고유 임무와 기능

- **국가측정표준 확립 및 유지 향상**
: 국가 측정표준 대표기관, 세계 측정표준 선도기관
- **측정과학기술 연구개발**
: 측정과학기술 연구기관, 측정과학 기술적시 공급
- **측정표준·측정과학기술 보급 및 서비스**
: 측정표준보급 정점기관, 산업협력 지원중심 기관

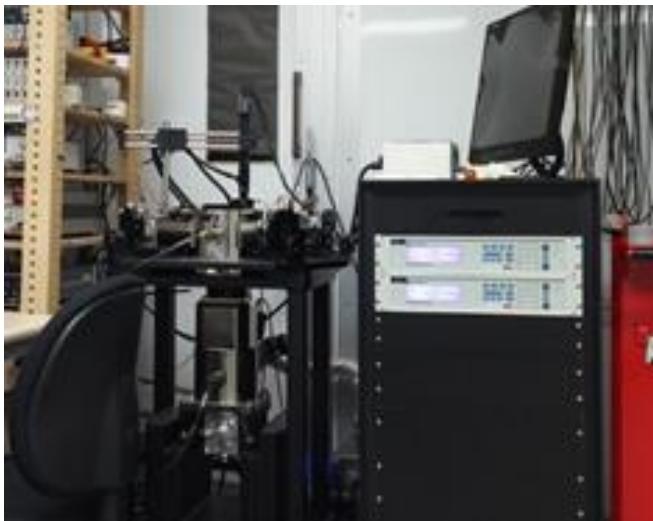




나노 소자 기반 양자물성 정밀 측정법 개발

KRISS 소자측정실험실

- Dilution Refrigerator (DR, 희석식 냉장고) (4)
 : Wet DRs (3), Cryogen-free DR (1)
- Cryogen-free Probe Station (무냉매 프로브스테이션)
- Adiabatic Demagnetization Refrigerators (ADR, 단열소자냉동기) (2)
- Pits for Liquid He Dewar (3)
- Tube Furnace (3), Wire bonders (2)



KRISS 나노팹

- SEM / E-beam lithography (2) : FEI Sirion 400, Raith Voyager
- Photolithography (2) : SUS Microtech MA6
- E-beam evaporators (5), Sputtering systems (2)
- Reactive Ion Etching (RIE, 2), Ion Milling
- Critical point dryer, Surface profiler, Plasma ashing
- Wet stations (solvent, acid and base bays), spin coaters, hot plates

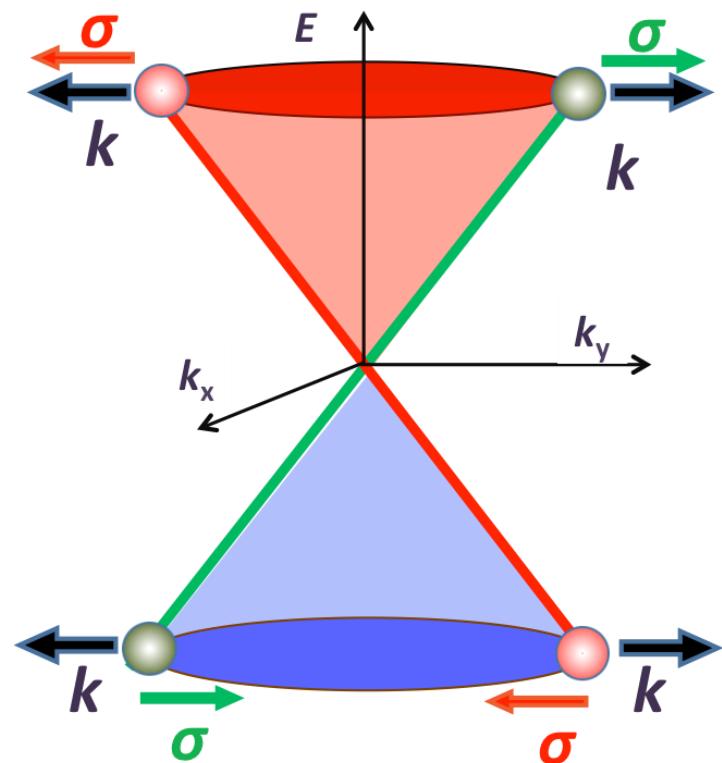
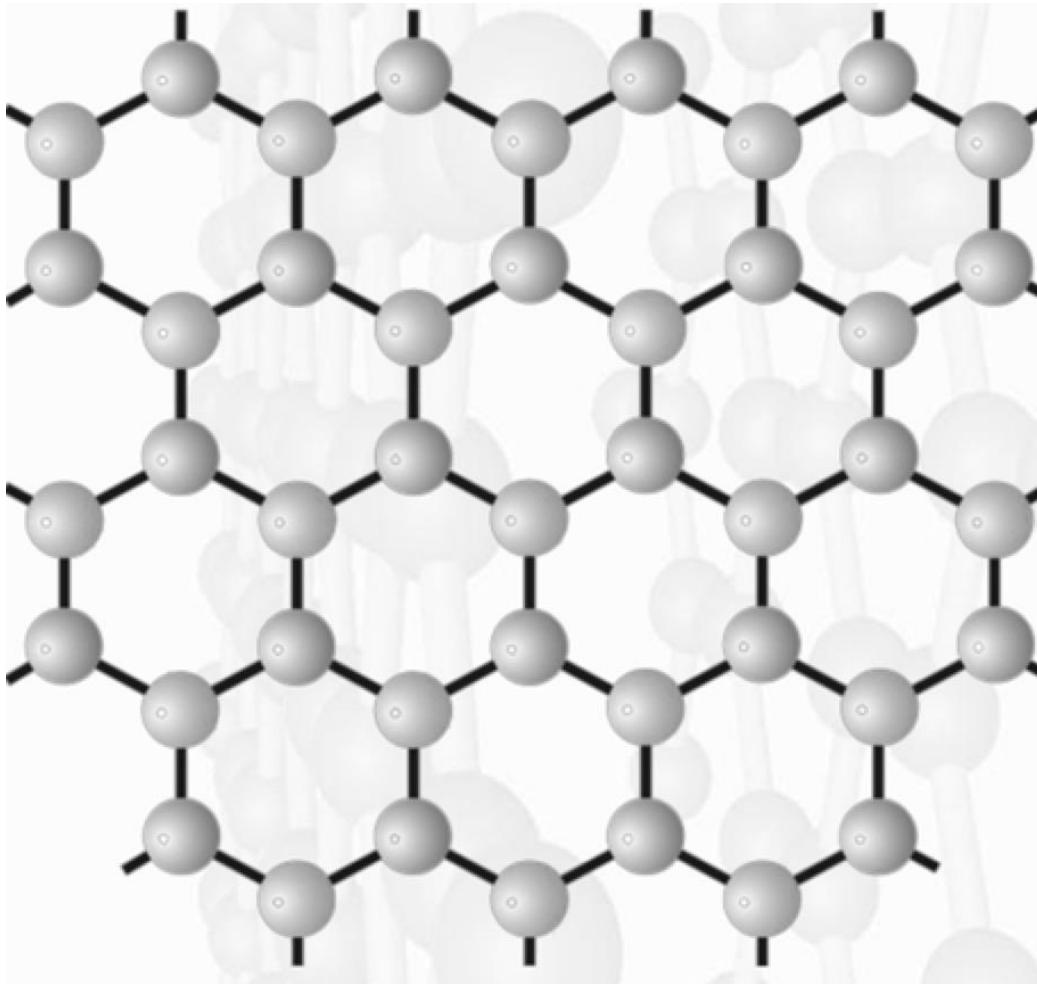


Energy gaps in graphene on *h*-BN substrate

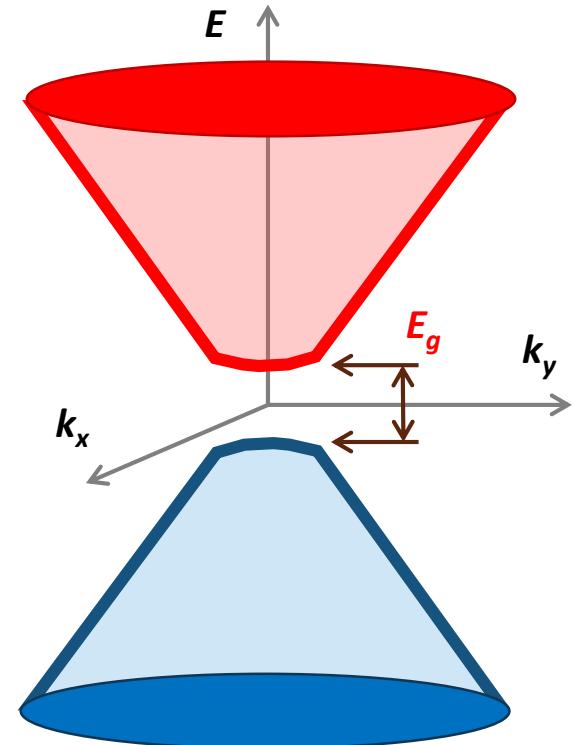
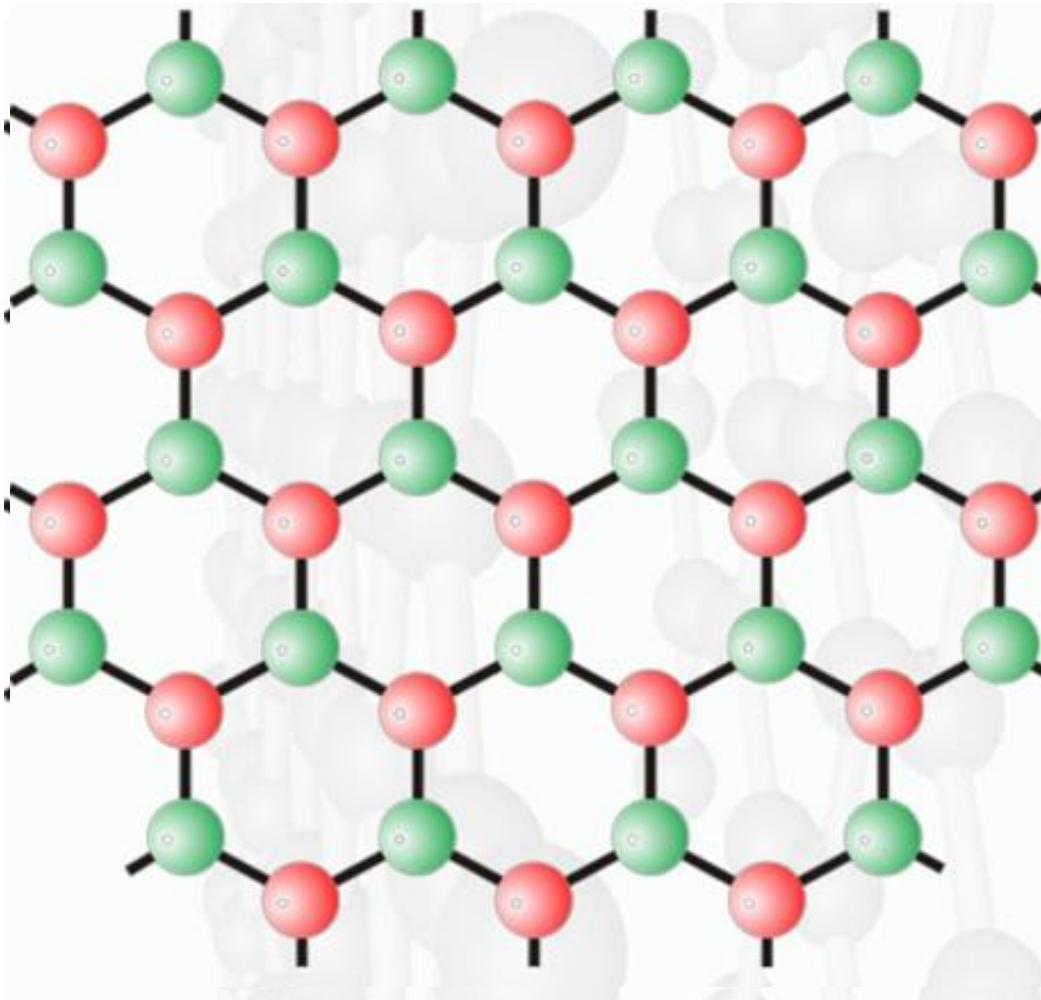
tunneling spectroscopy
with *h*-BN as a tunnel insulator

and others

Sublattice Symmetry of Graphene / Energy Gap

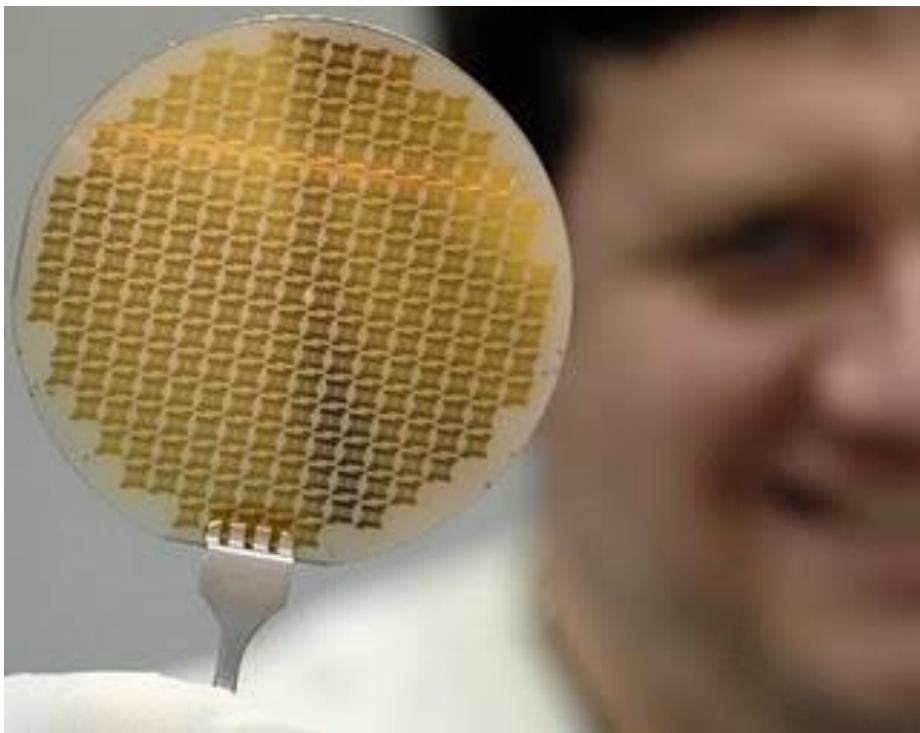


Sublattice Symmetry of Graphene / Energy Gap



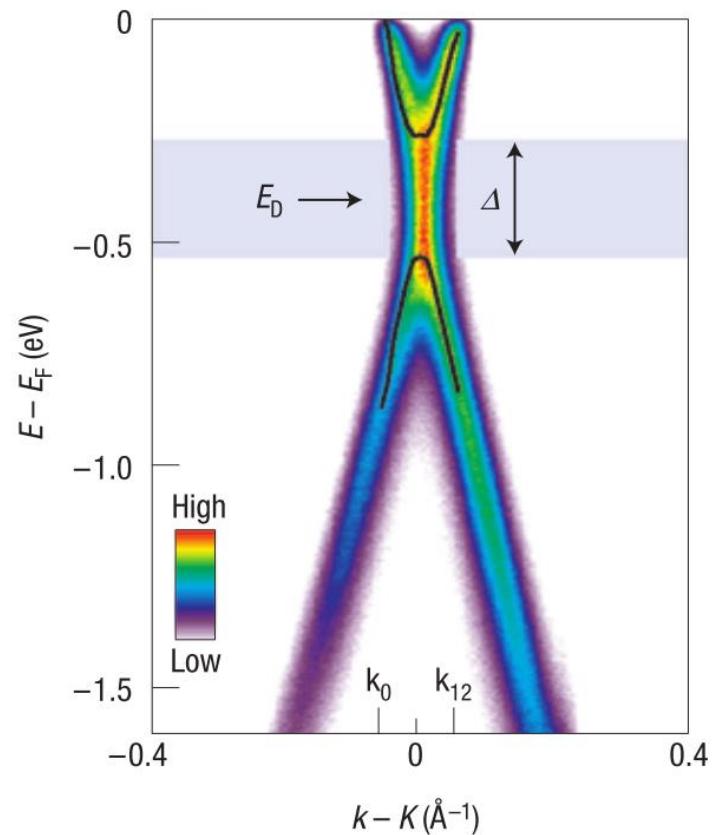
Experimental Evidence for Graphene Energy Gap

KRISs



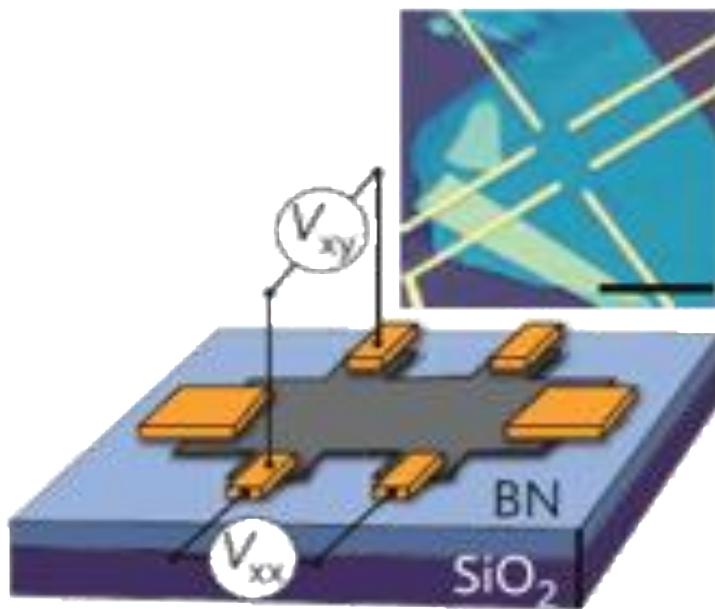
Courtesy of
Electro-Optics Center (EOC) Materials Division at Penn State

Graphene on SiC
(ARPES)



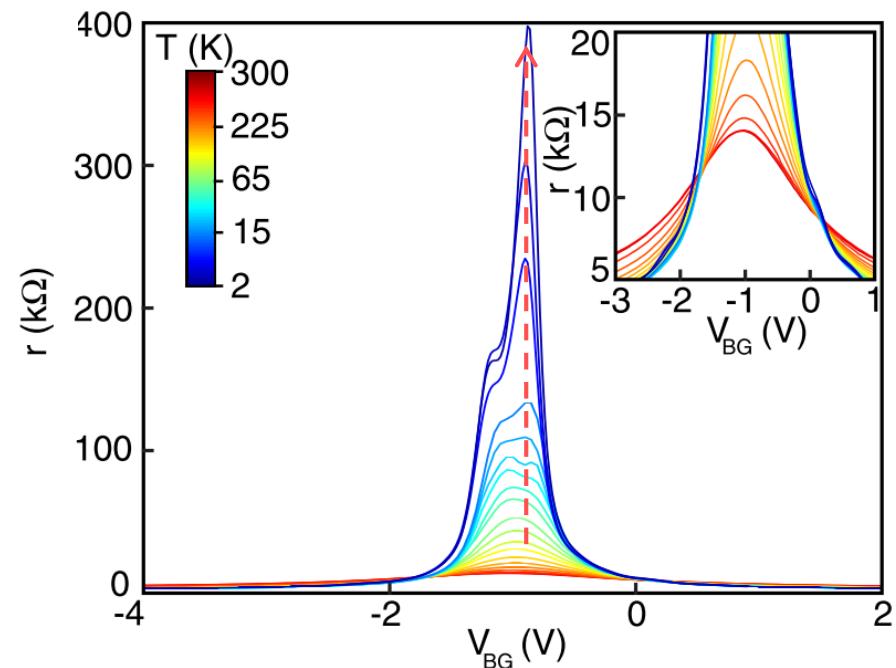
S. Zhou *et al.* Nat. Mater. **6**, 770 (2007)

Experimental Evidence for Graphene Energy Gap



C. R. Dean *et al.* Nature Physics **7**, 693 (2011)

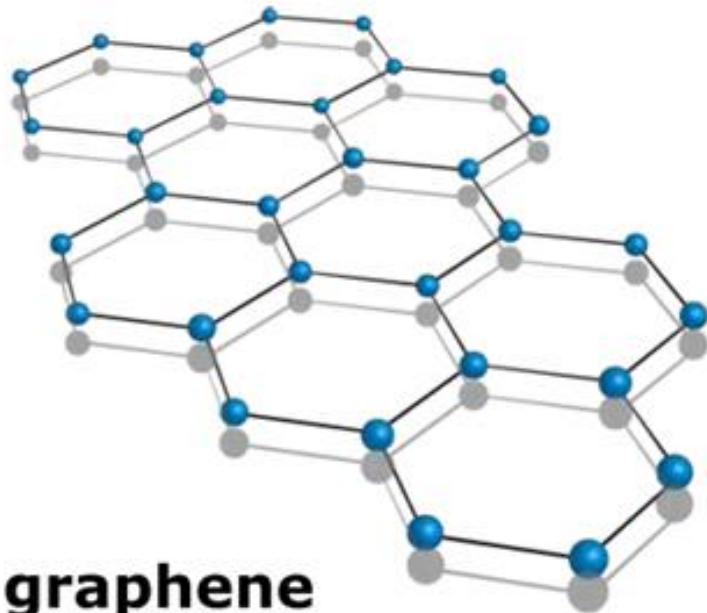
Graphene on *h*-BN
(multi-probe transport measurement)



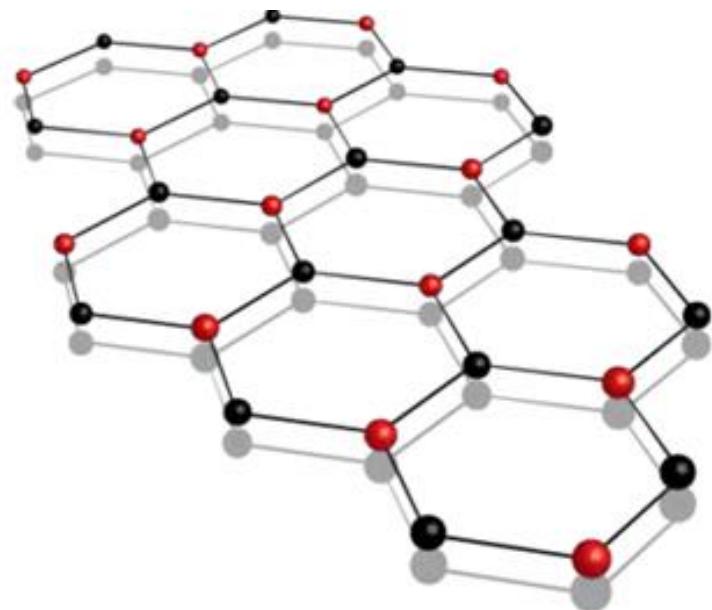
F. Amet *et al.* Phys. Rev. Lett. **110**, 216601 (2013)

Graphene vs. hexagonal Boron Nitride

KRISs



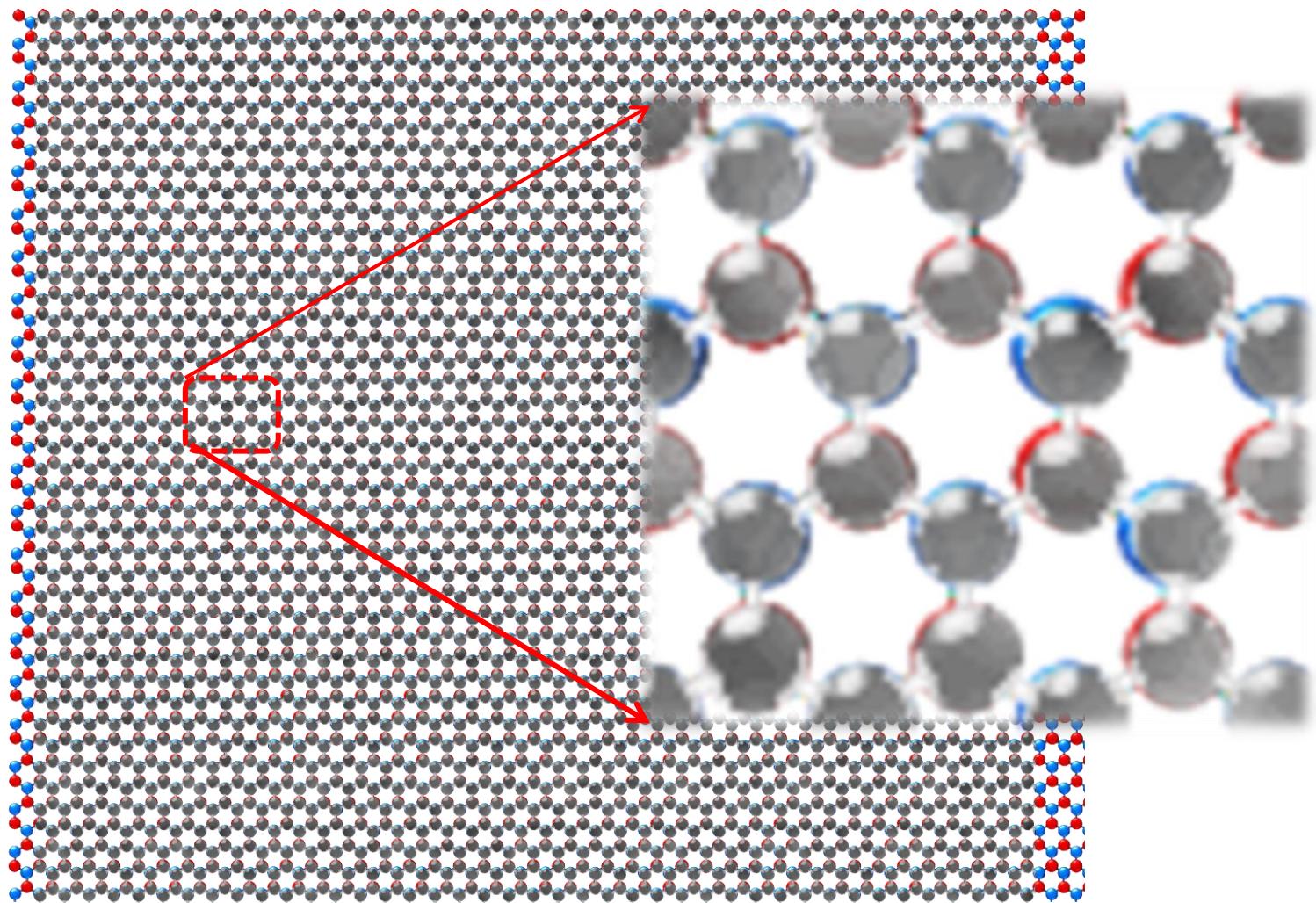
graphene



Boron Nitride

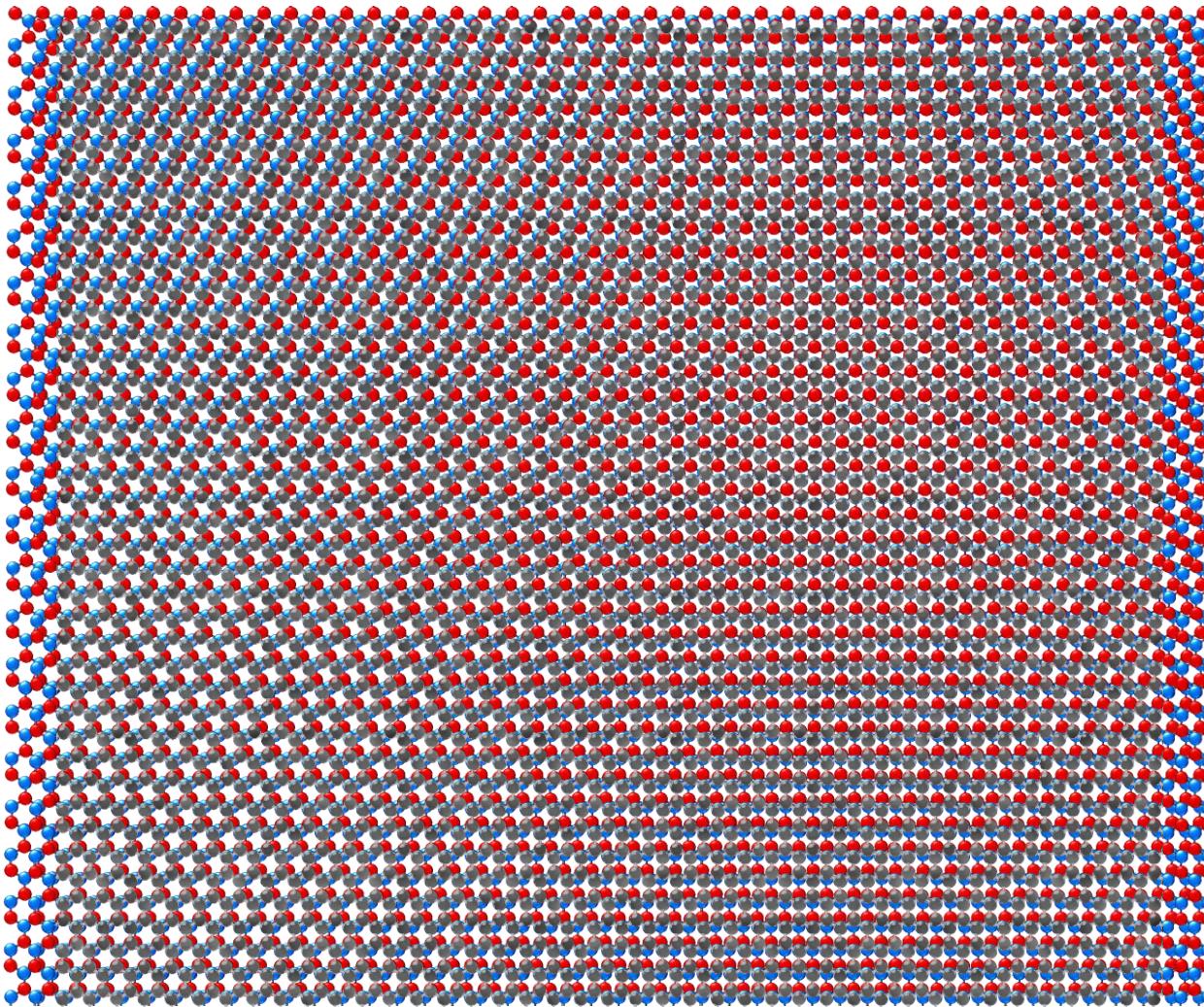
Graphene Superlattices on hexagonal boron nitride

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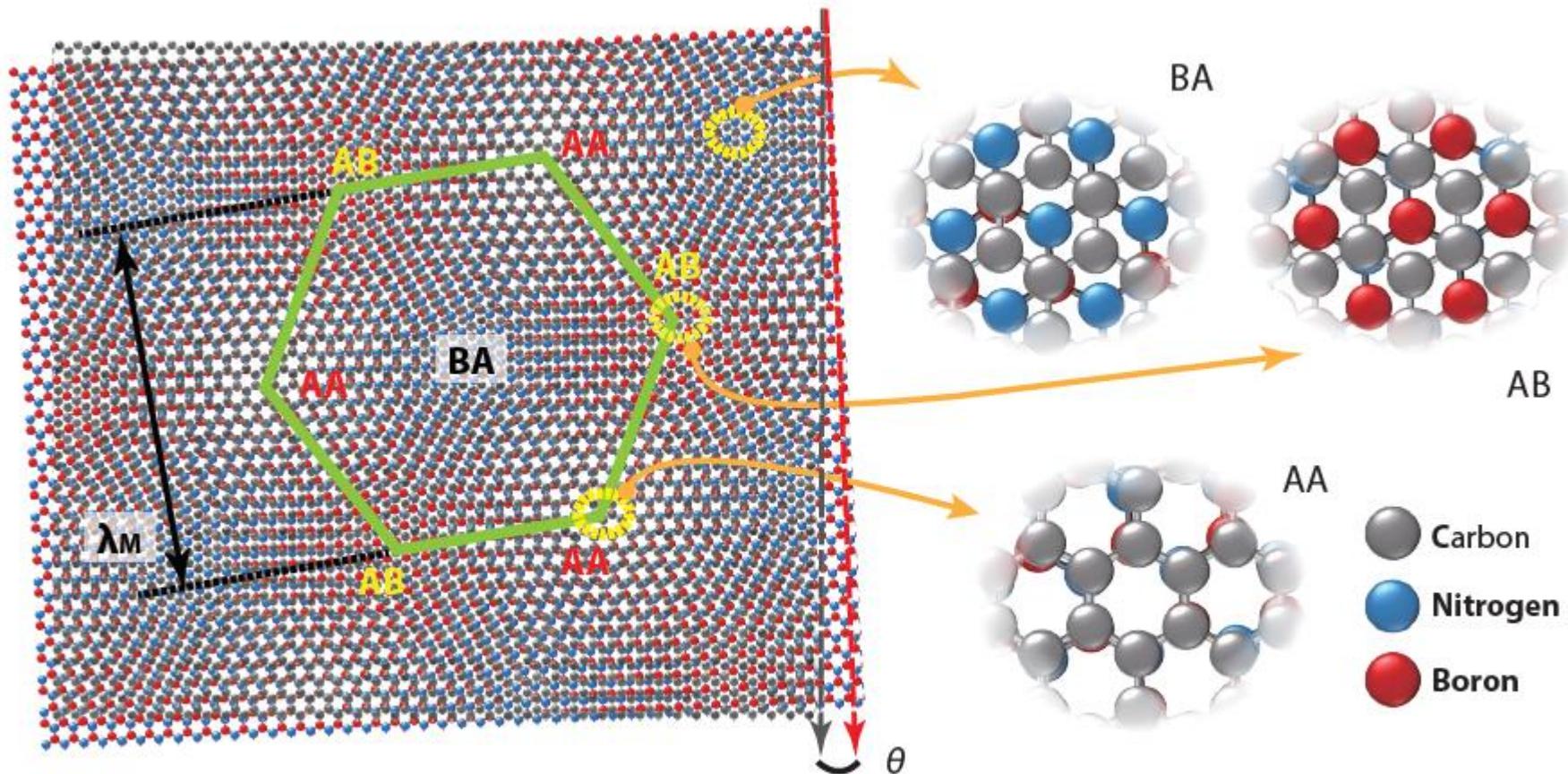


Graphene Superlattices on hexagonal boron nitride

KRISs

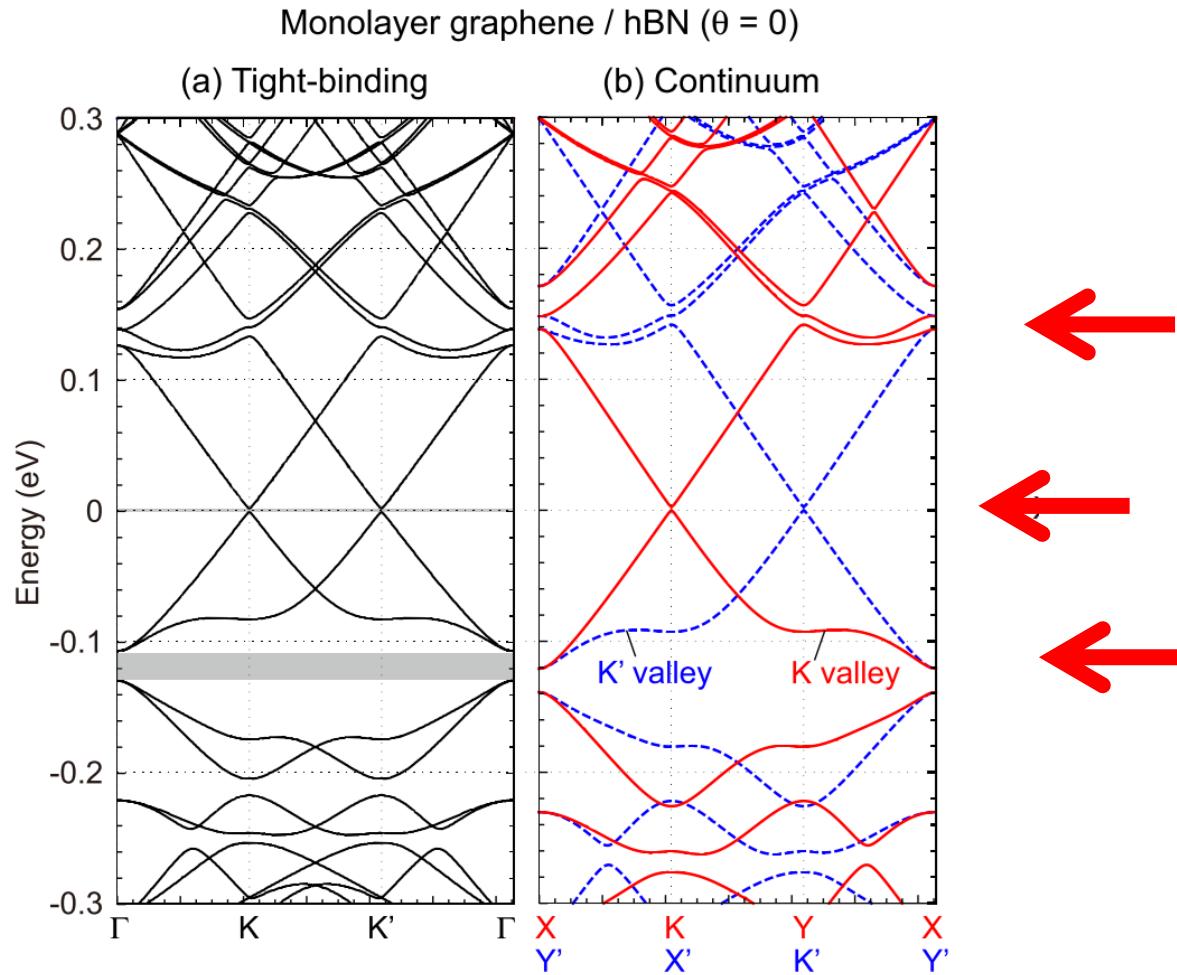


Graphene Superlattices on hexagonal boron nitride KRISS



Graphene Superlattices on hexagonal boron nitride KRISS

Band Structure of Graphene Superlattice

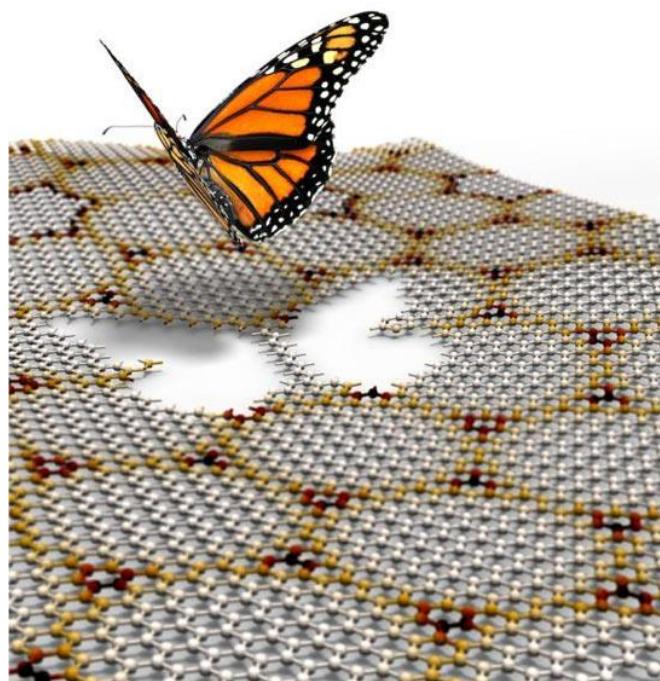
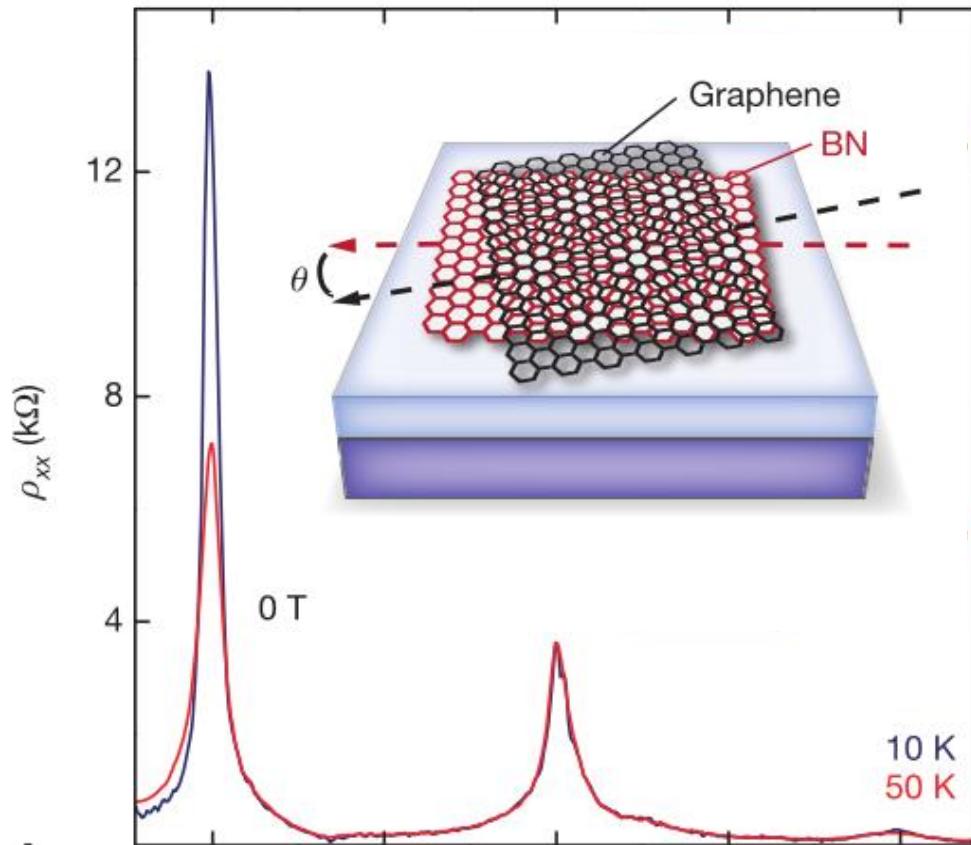


P. Moon et al. Phys. Rev. B 90, 155406 (2014)

Graphene Superlattices on *h*-BN

KRISs

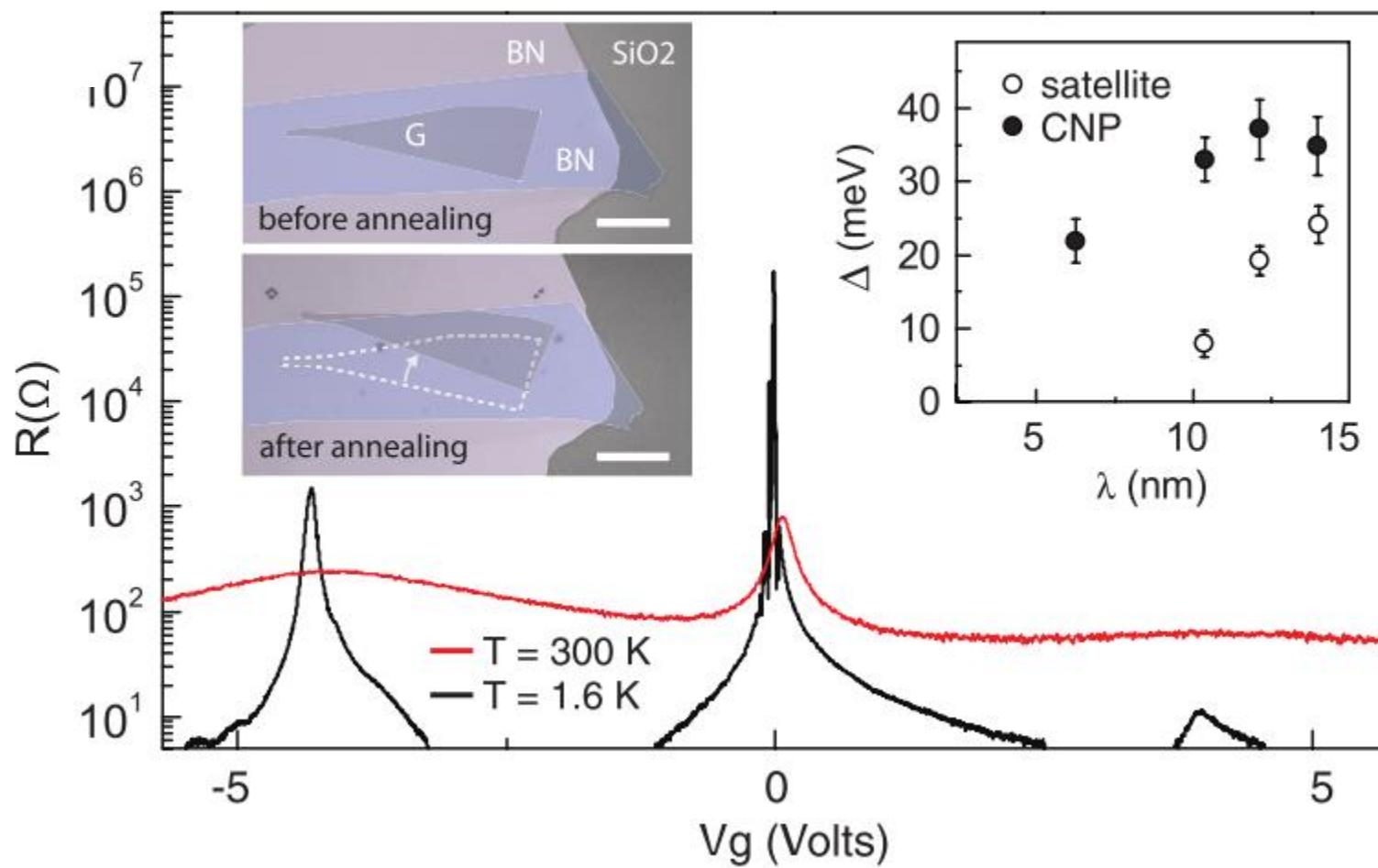
Experimental evidence for the 2nd Dirac points in graphene superlattice



C. R. Dean *et al.* Nature (2013) - ***bilayer***
L.A. Ponomarenko *et al.* Nature (2013) – ***single layer***
B. Hunt *et al.* Science (2013) – ***single layer***

Quantitative Analysis for the Energy Gaps

KRIS

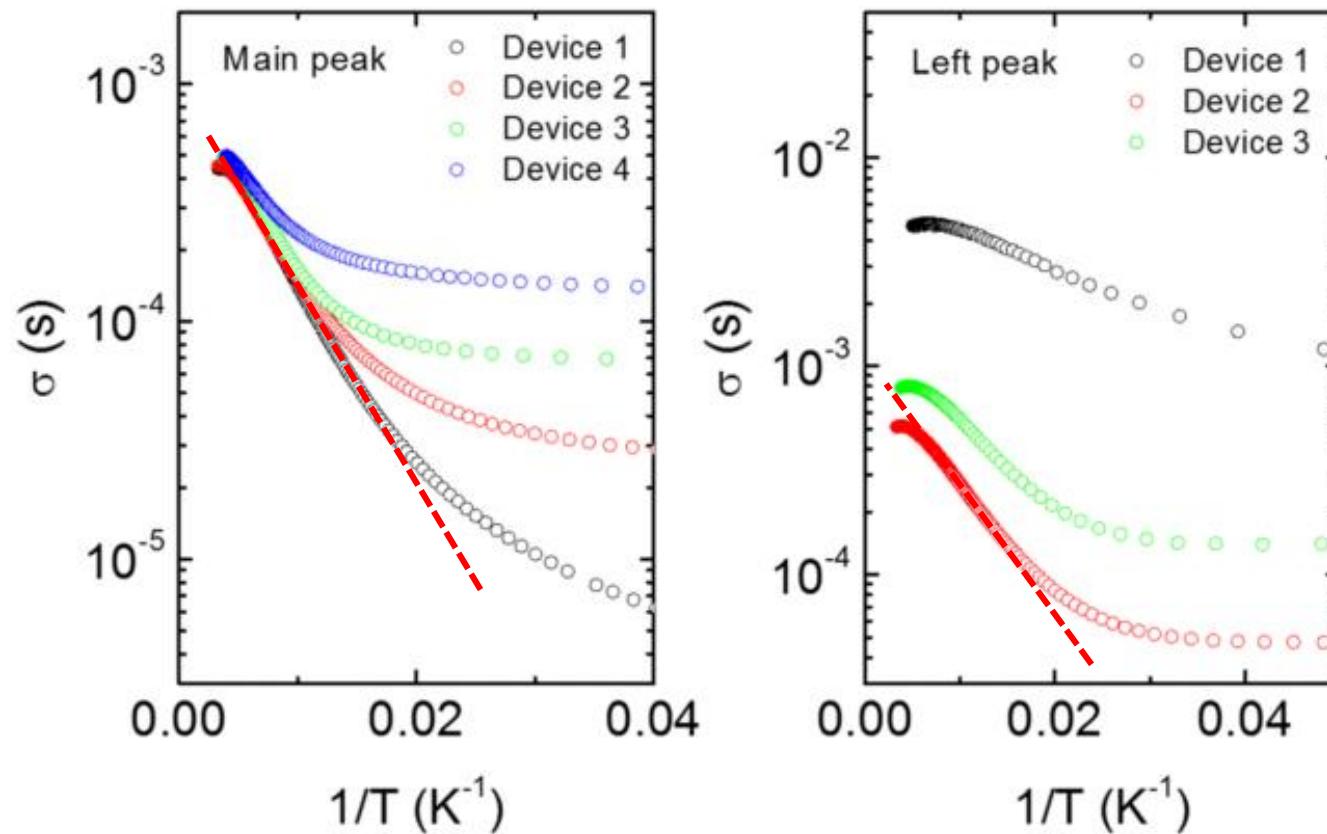


L. Wang *et al.* Science **350**, 1231-1234 (2015)

Quantitative Analysis for the Energy Gaps

KRIS

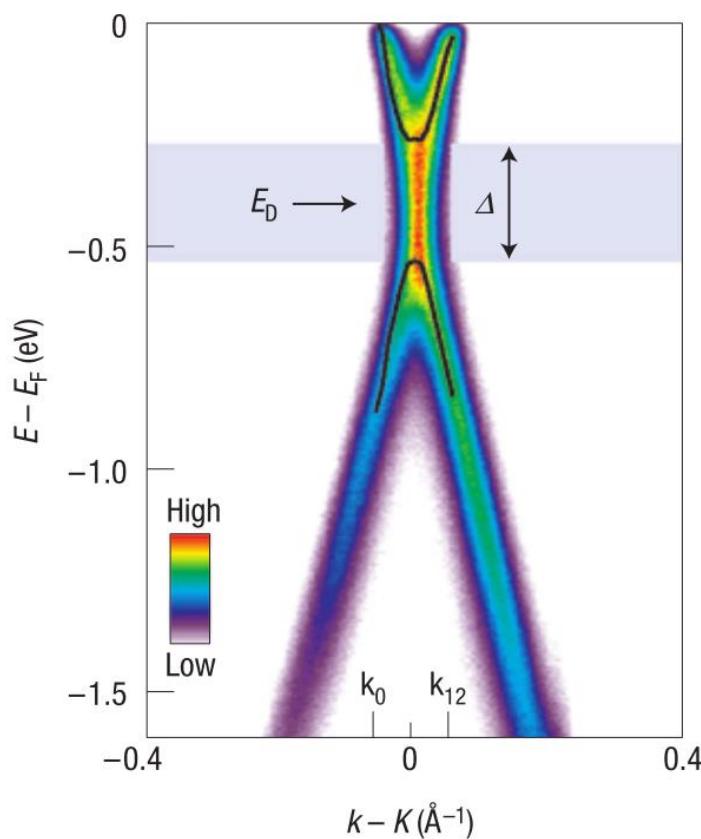
Extracting the energy gaps from Arrhenius plot of the peak conductivities



L. Wang *et al.* Science **350**, 1231-1234 (2015)

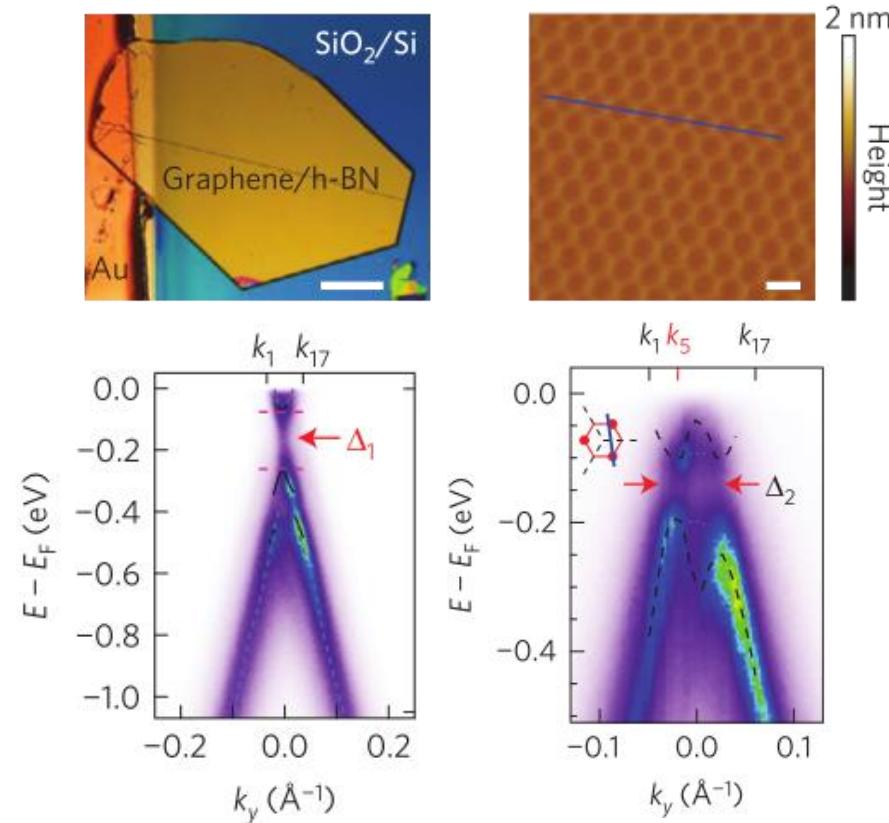
Alternative Method for Probing the Energy Gaps

Graphene on SiC
(ARPES)



S. Zhou *et al.* Nat. Mater. **6**, 770 (2007)

Graphene on *h*-BN
(ARPES)

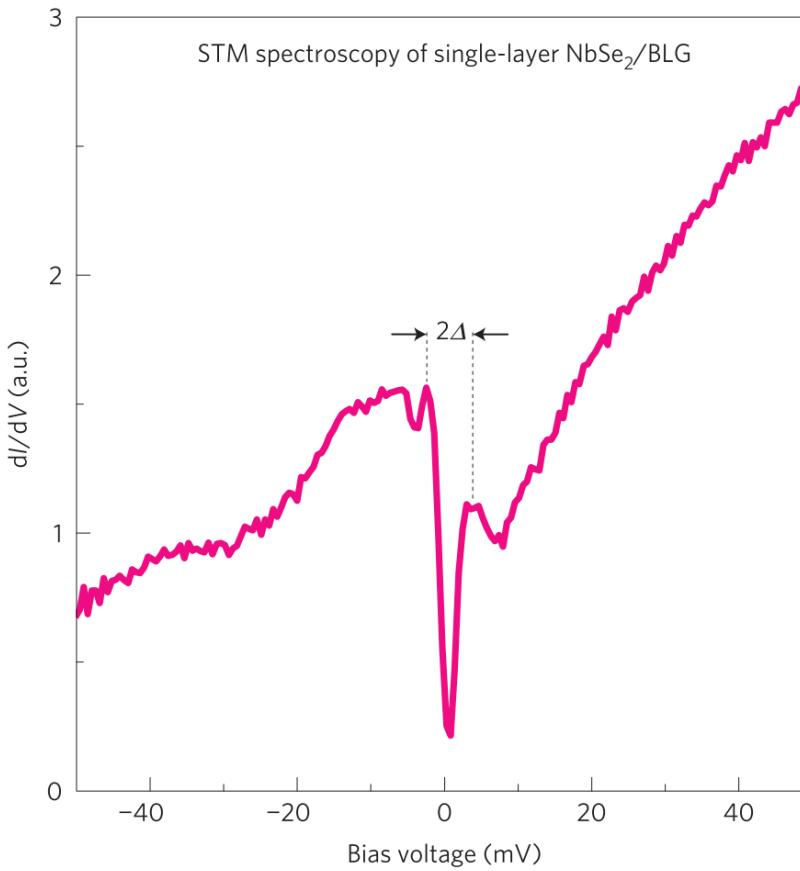


E. Wang *et al.* Nat. Phys. **12**, 1111 (2016)

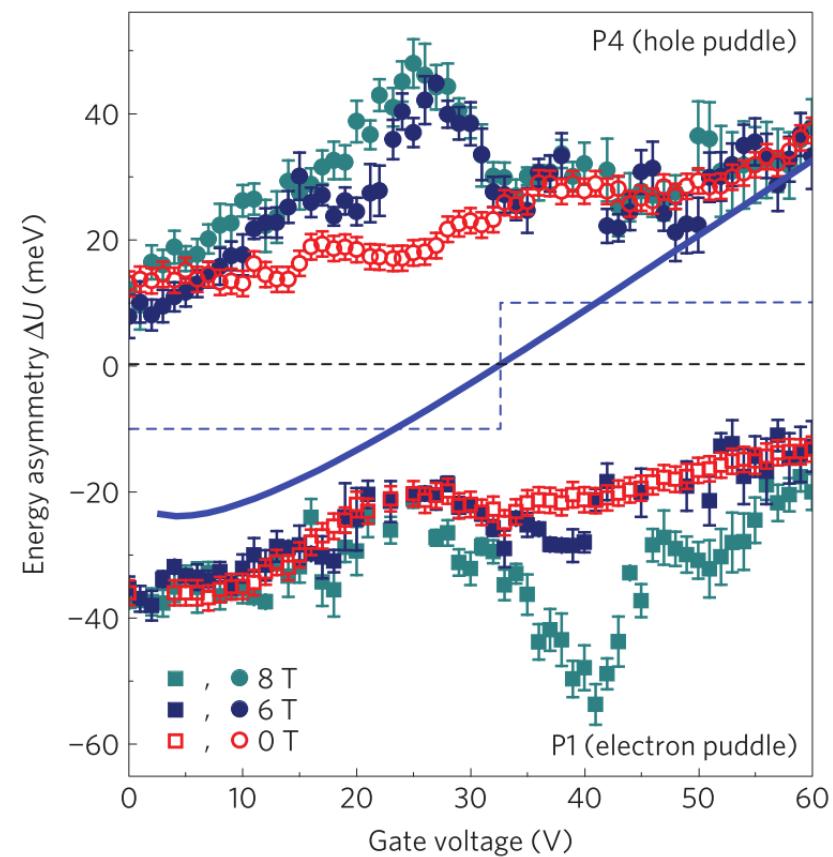
Tunneling Spectroscopy for Probing Energy Gaps

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Gap from Charge-Density Wave in NbSe₂
(STM)



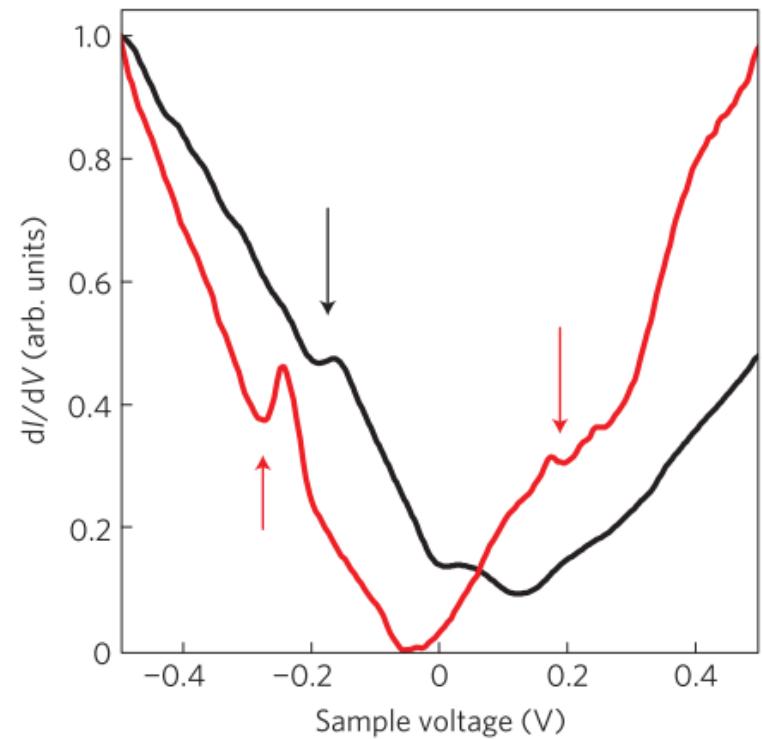
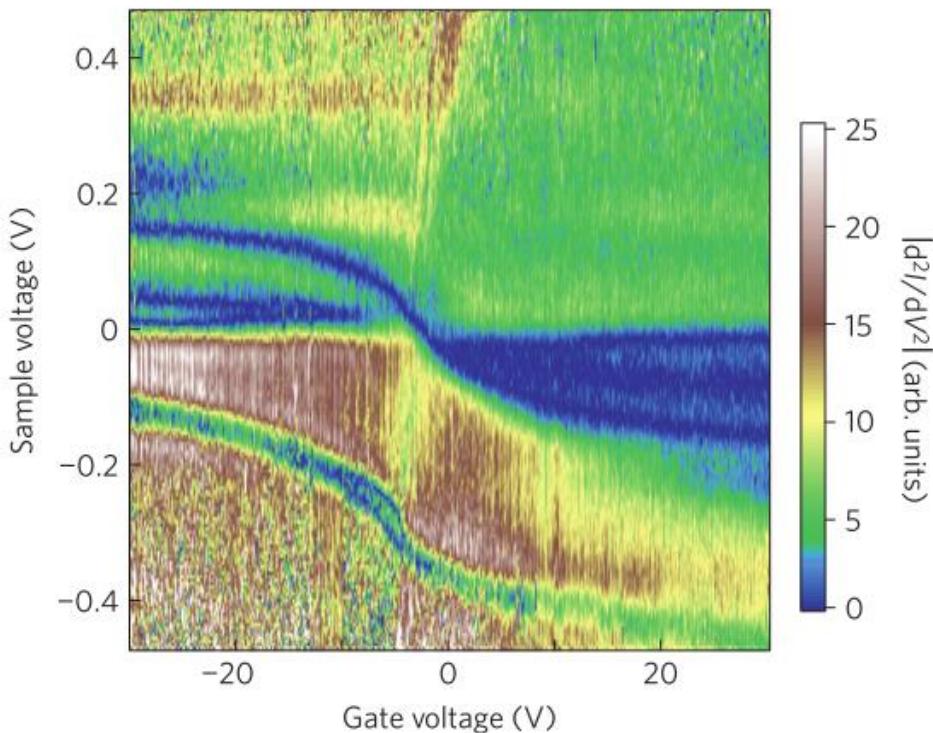
Energy Gap in Bilayer Graphene
(STM)



M. Ugeda *et al.* Nat. Phys. **12**, 92-97 (2016)

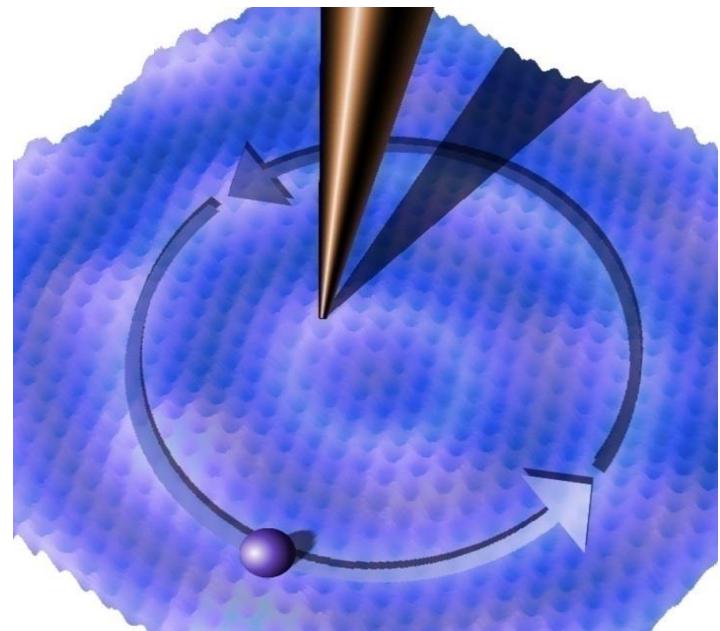
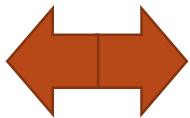
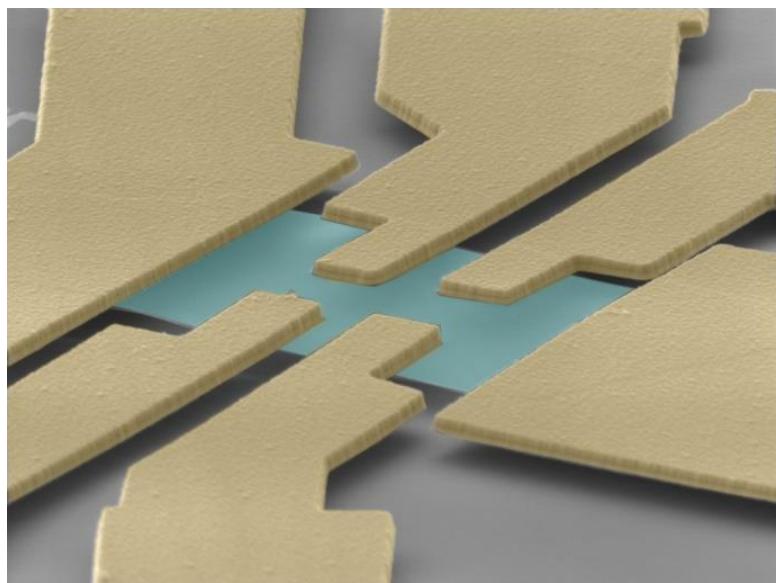
G. Rutter *et al.* Nat. Phys. **7**, 649-655 (2011)

STM / STS Measurement



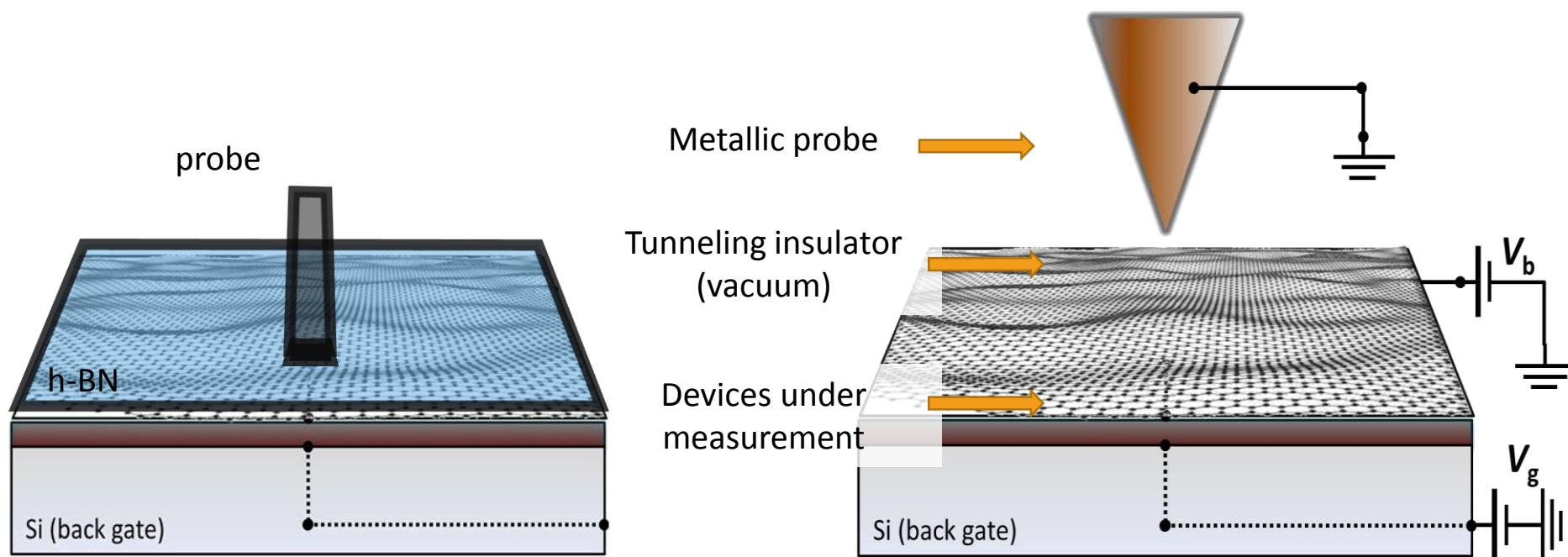
M. Yankowitz *et al.* Nat. Phys. **8**, 382-386 (2012)

Tunneling Spectroscopy for Probing Energy Gap



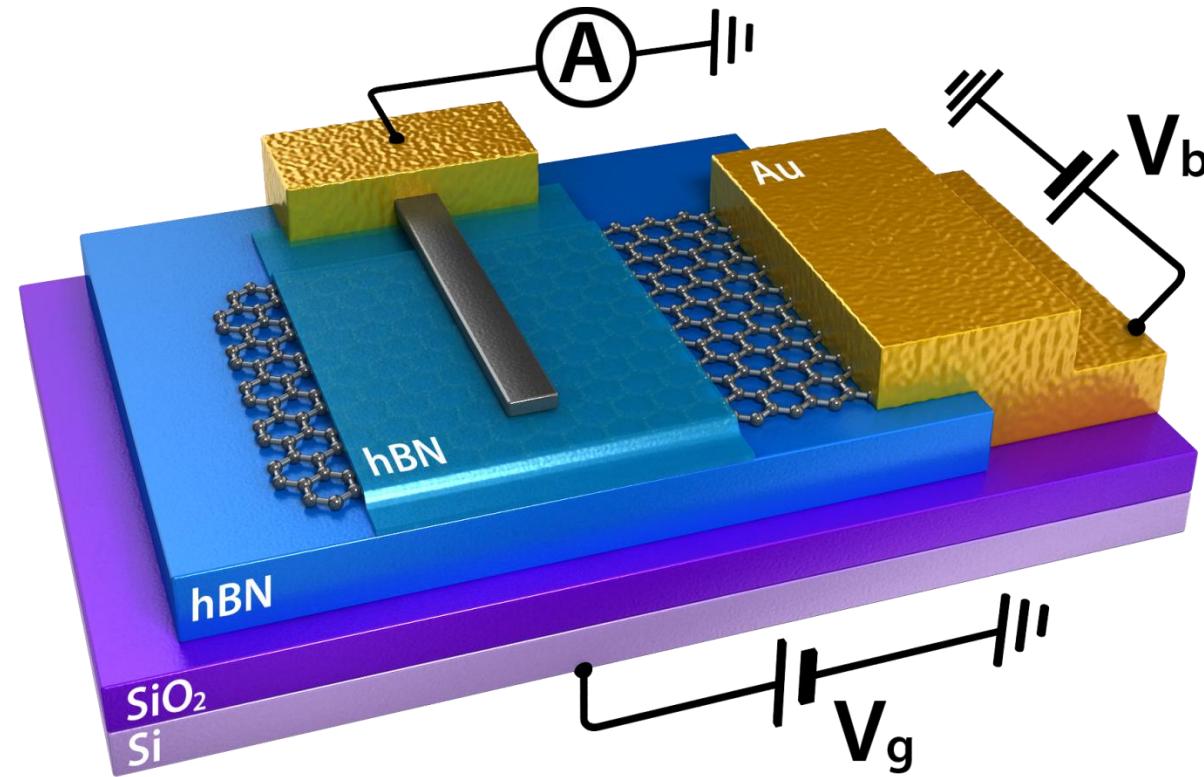
Tunneling Spectroscopy with h-BN as Insulator

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Tunneling Spectroscopy with h -BN

KRISs



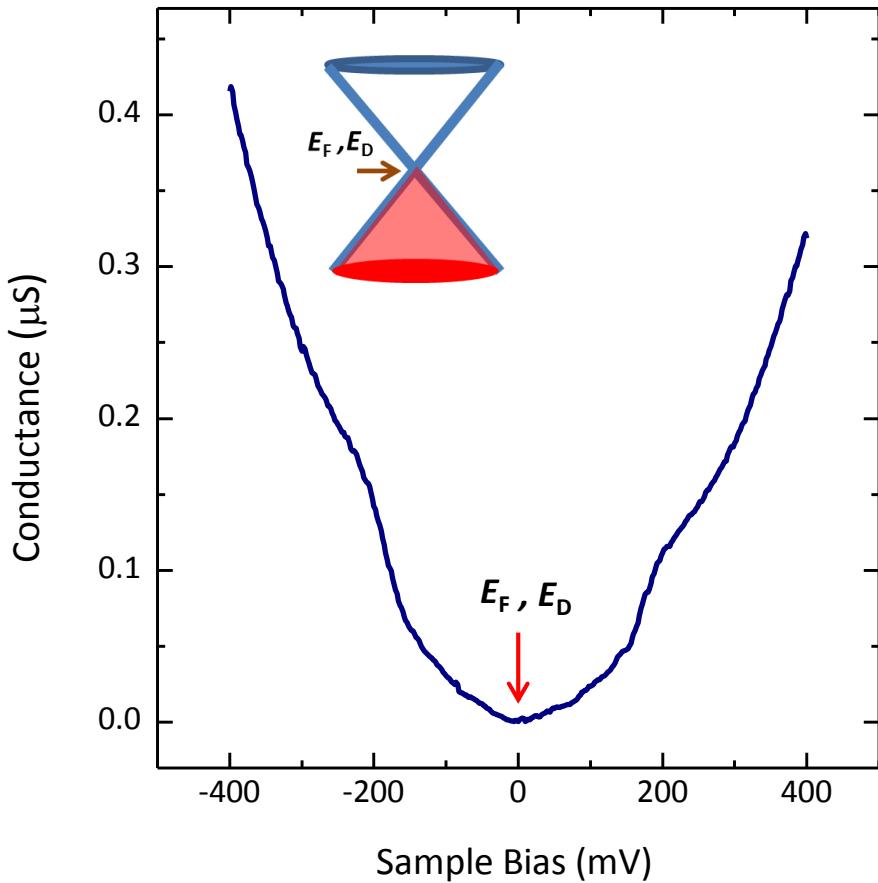
S. Jung *et al.* *Sci. Rep.* **5**, 16642 (2015)

S. Jung *et al.* *Nano Lett.* **17**, 206-213 (2017)

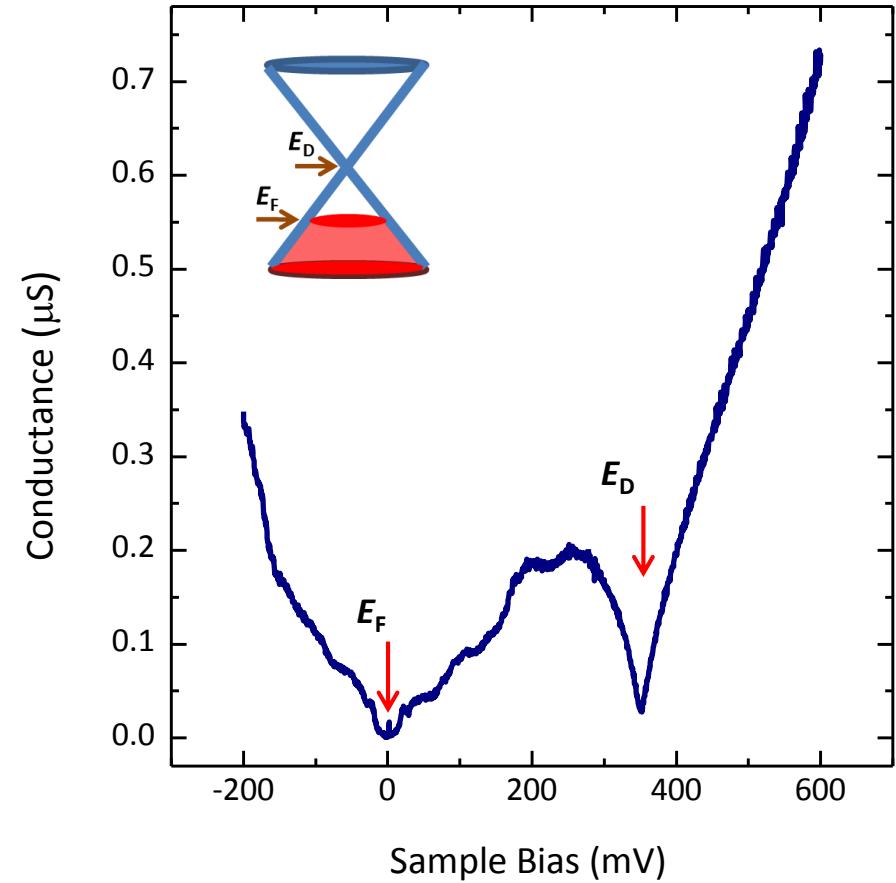
Tunneling Spectroscopy of Single Layer Graphene

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@ charge neutrality point ($V_g = 0$ V)

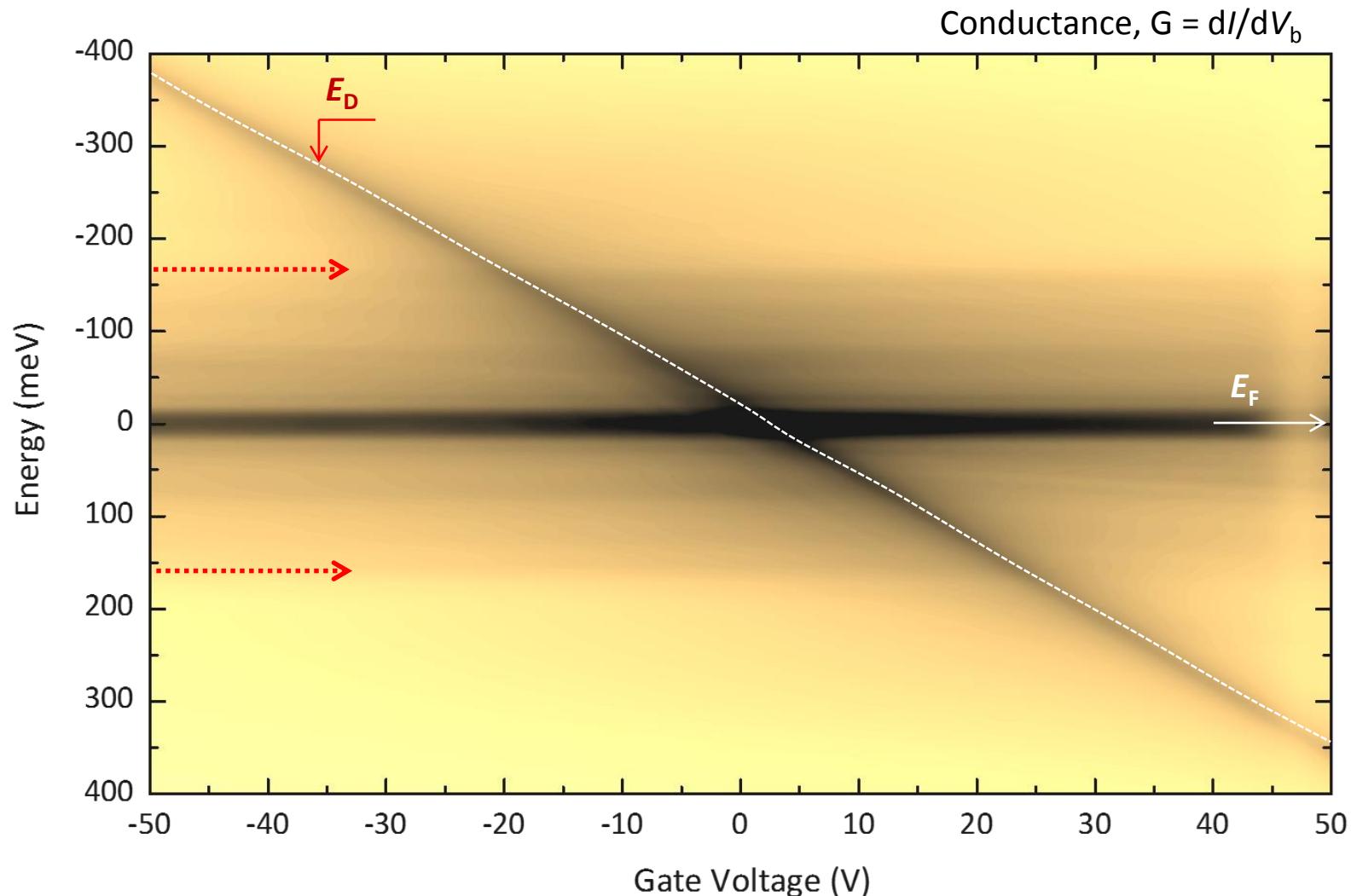


@ hole doping region ($V_g = -50$ V)



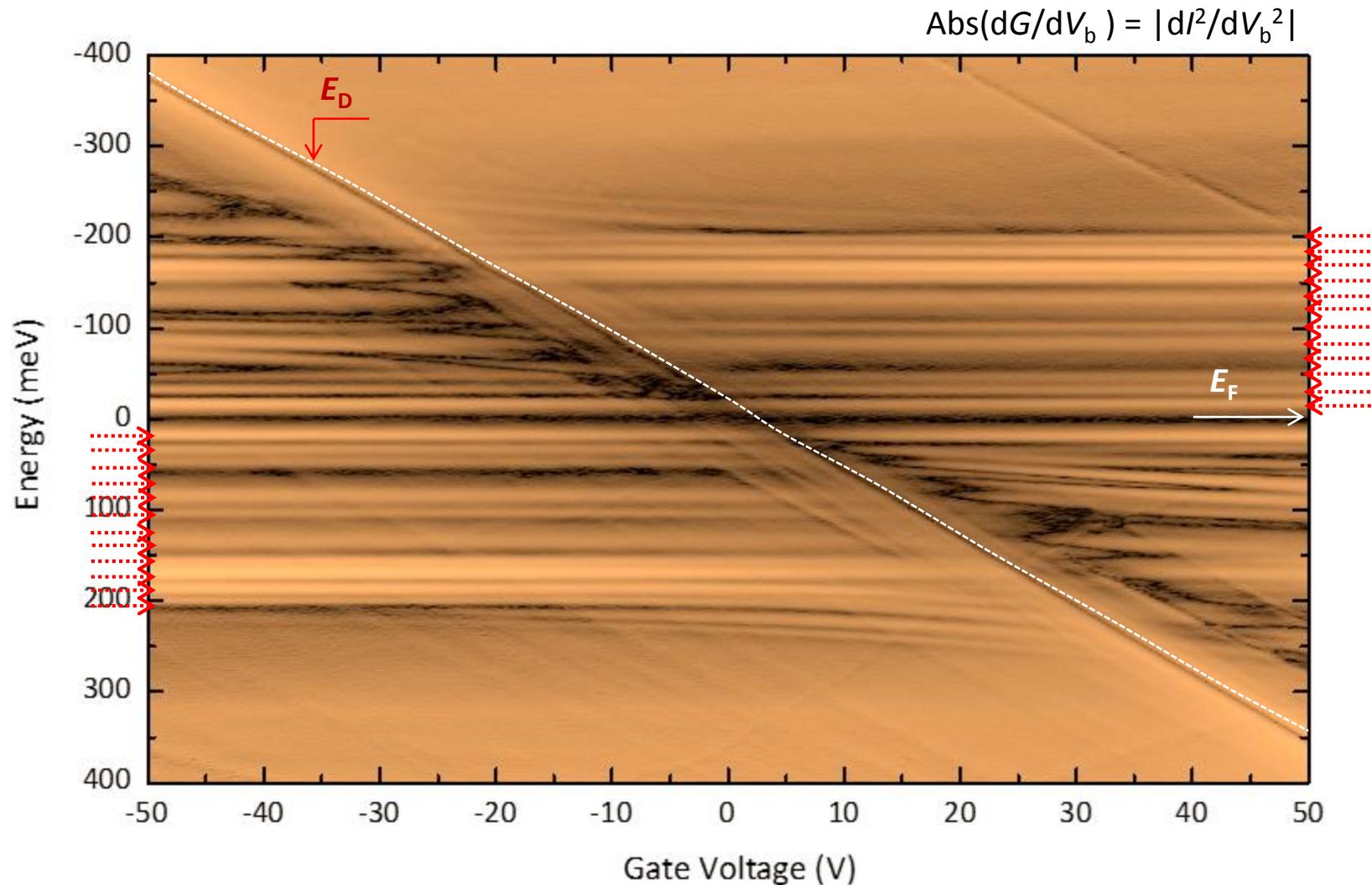
Gate Mapping of Single-Layer Graphene

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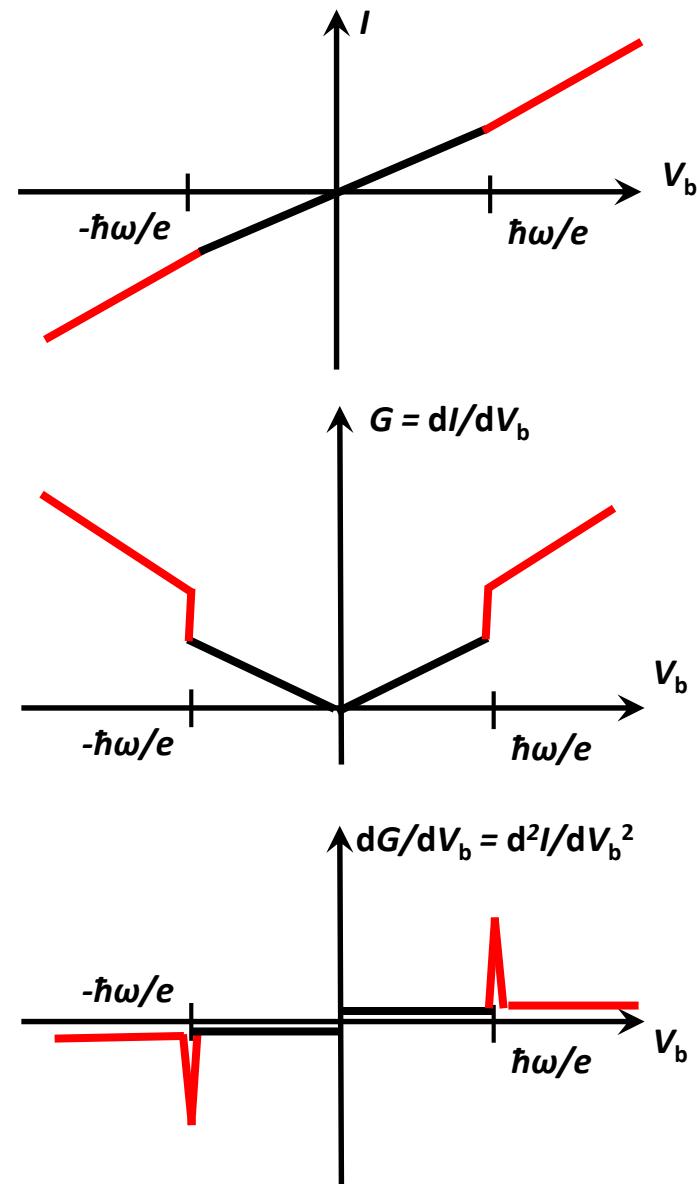
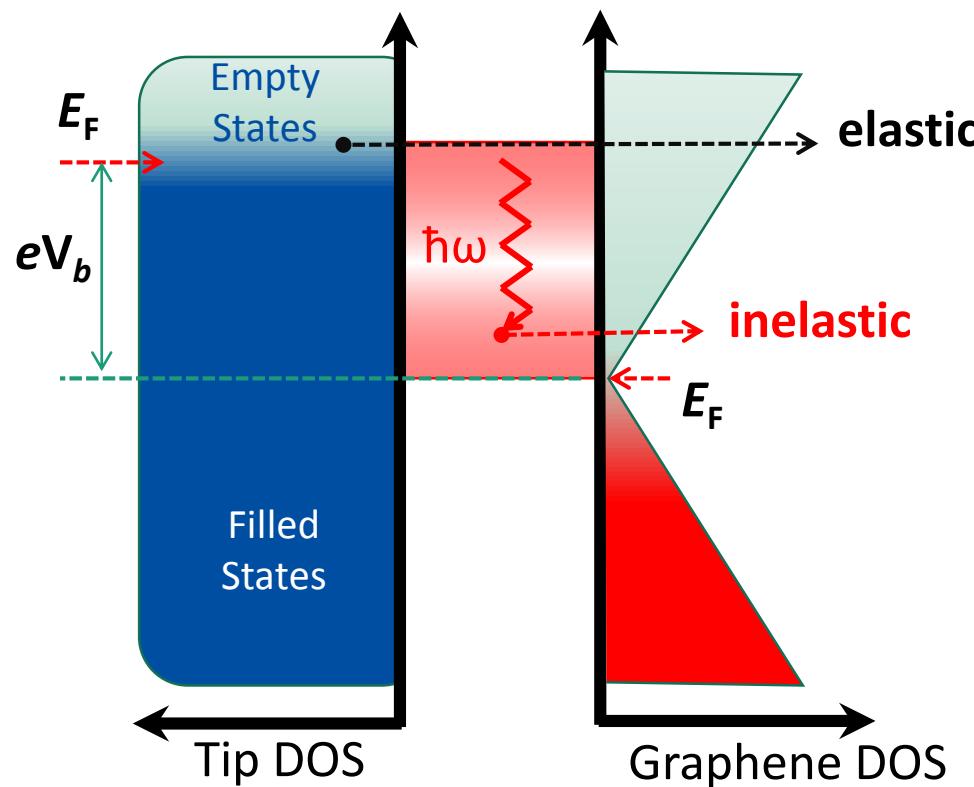
Inelastic Tunneling Spectroscopy (Phonons)

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Inelastic Electron Tunneling Spectroscopy (Phonons) KRISS

- Inelastic Electron Tunneling Spectroscopy

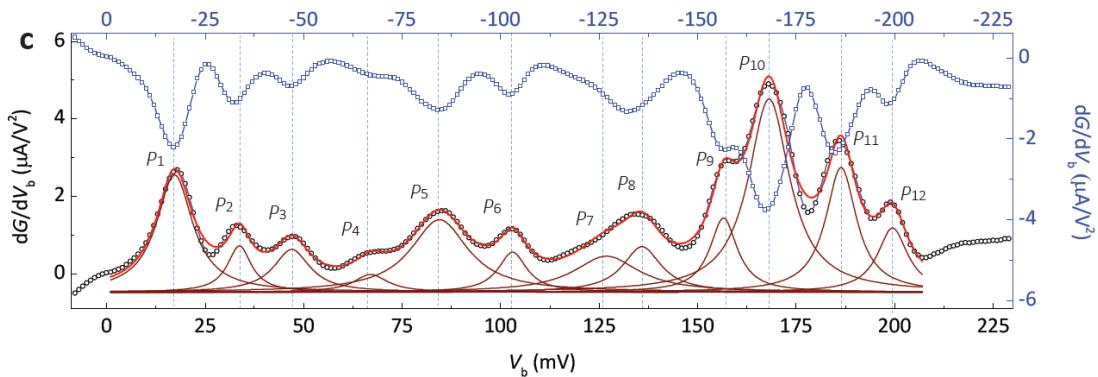
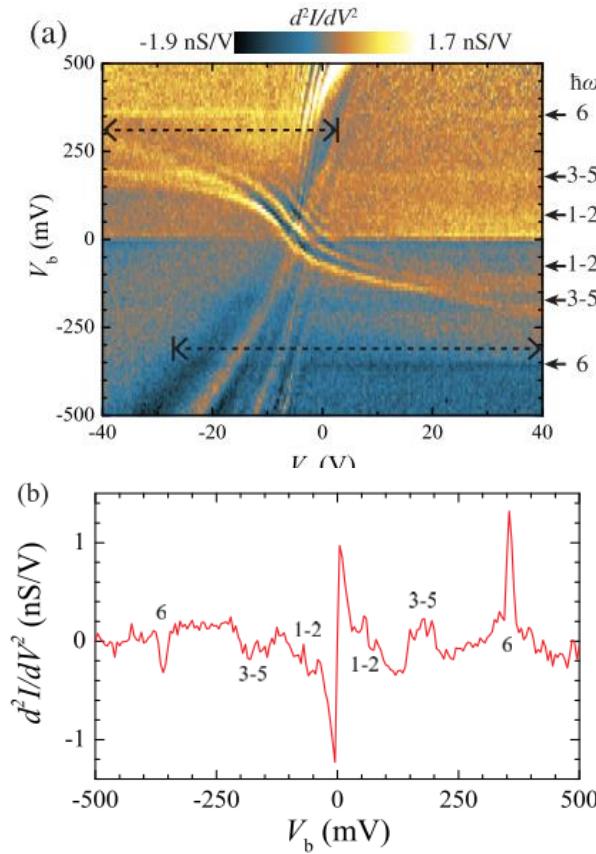


Inelastic Electron Tunneling Spectroscopy (Phonons) KRISS

STM measurement

IETS for graphene phonons

F. D. Natterer et al. Phy. Rev. Lett. (2015)

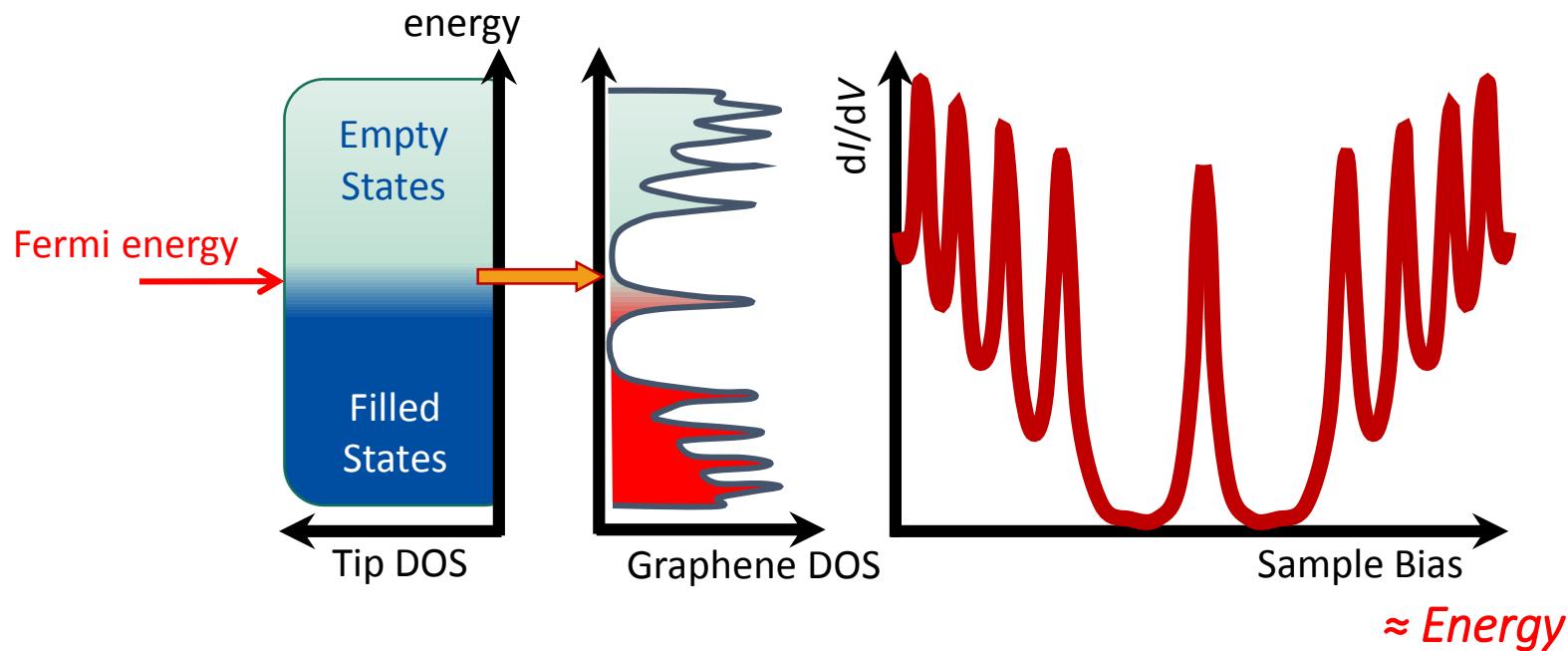


Density Functional Perturbation Theory (DFPT) Calculation

Peak No.	Position (mV)	FWHM (mV)	Phonons	DFT (meV)
1	16.7 ± 0.1	11.6 ± 0.6	Γ_{4+} (<i>h-BN</i>) / Γ_{6-}, Γ_{2-} (<i>graphite</i>)	11 / 14
2	33.5 ± 0.3	7.8 ± 1.0	Γ_6, Γ_2 (<i>graphene/h-BN hetero</i>)	36
3	46.4 ± 0.4	12.6 ± 1.7	K_6 (<i>graphene/h-BN hetero</i>)	46
4	66.7 ± 1.7	7.8 ± 6.9	K_6 (<i>graphite/graphene</i>)	67
5	83.8 ± 0.3	18.1 ± 1.5	M_{2+} (<i>graphene/h-BN hetero</i>)	86
6	102.9 ± 0.3	9.4 ± 1.5	Γ_3, Γ_{4+} (<i>h-BN</i>) / Γ_{4+} (<i>graphite</i>)	99 / 110
7	124.7 ± 2.4	19.7 ± 5.8	K_5 (<i>h-BN</i>) / K_2 (<i>graphite</i>)	129 / 124
8	134.8 ± 0.6	11.5 ± 2.5	K_5 (<i>graphene/h-BN hetero</i>)	140
9	156.4 ± 0.2	7.6 ± 0.7	$K_{1,2}$ (<i>h-BN</i>)	155
10	167.9 ± 0.1	12.6 ± 0.4	Γ_{5+} (<i>h-BN</i>)	167
11	186.3 ± 0.1	9.3 ± 0.4	LO overbending (<i>h-BN</i>)	184
12	199.2 ± 0.2	7.1 ± 0.7	Γ_{5+} / LO overbending (<i>graphite</i>)	198 / 202

Probing Electronic Structure with Tunneling

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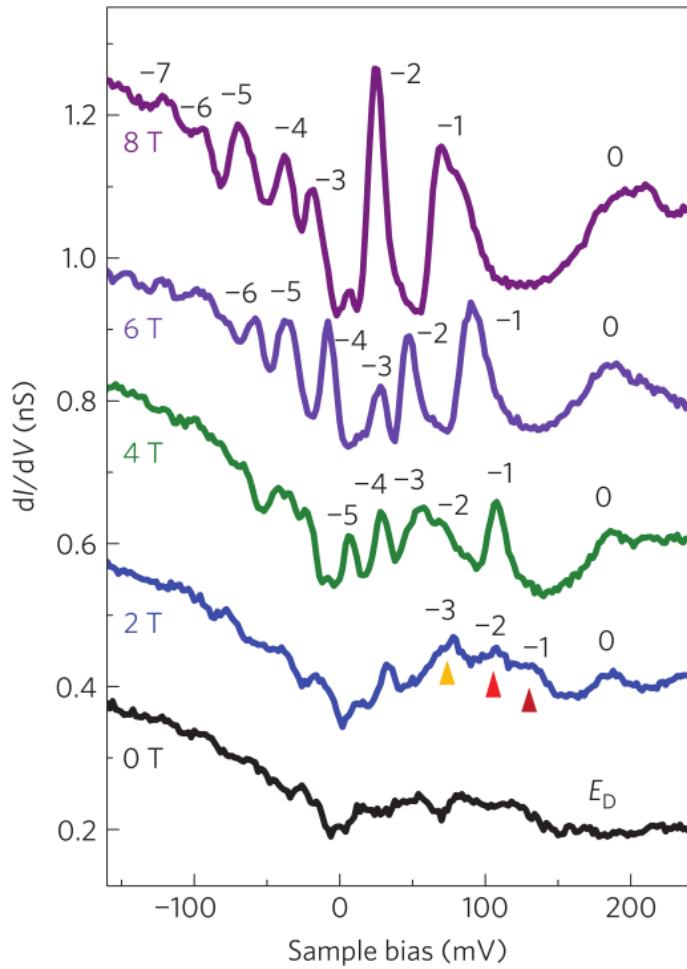


Tunneling Spectroscopy in High Magnetic Field

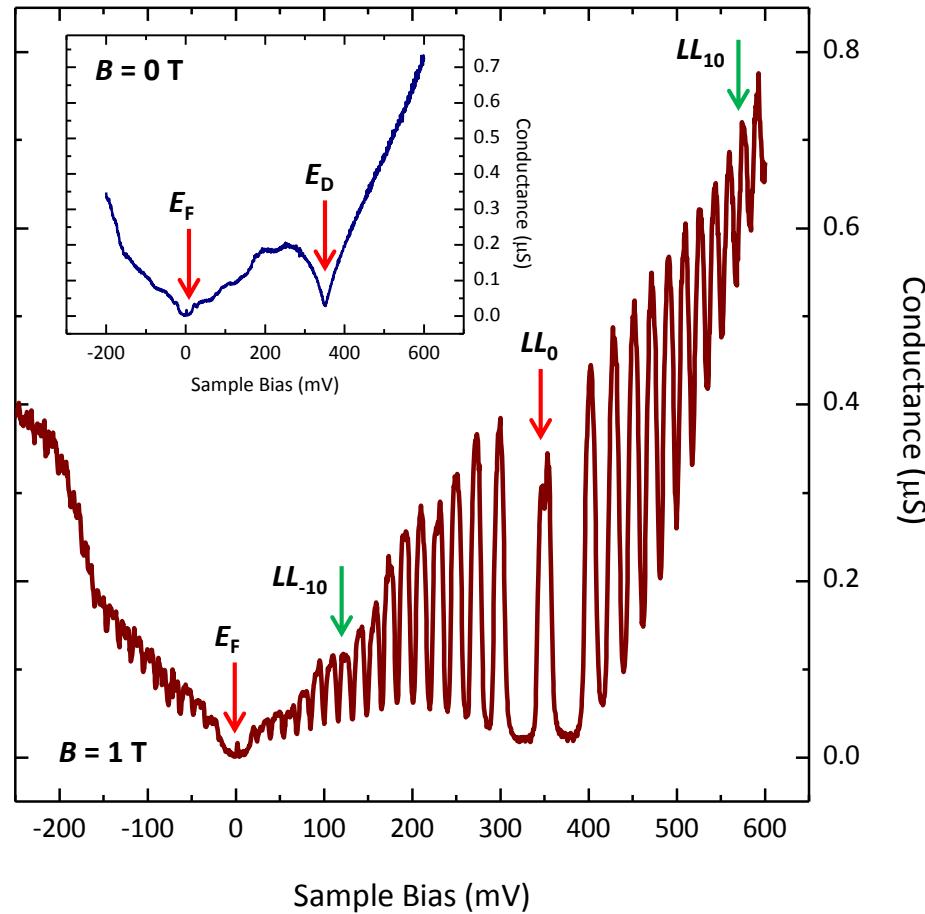
KRRISS

STM measurement

S. Jung et al. Nat. Phys. **7**, 245-251 (2011)



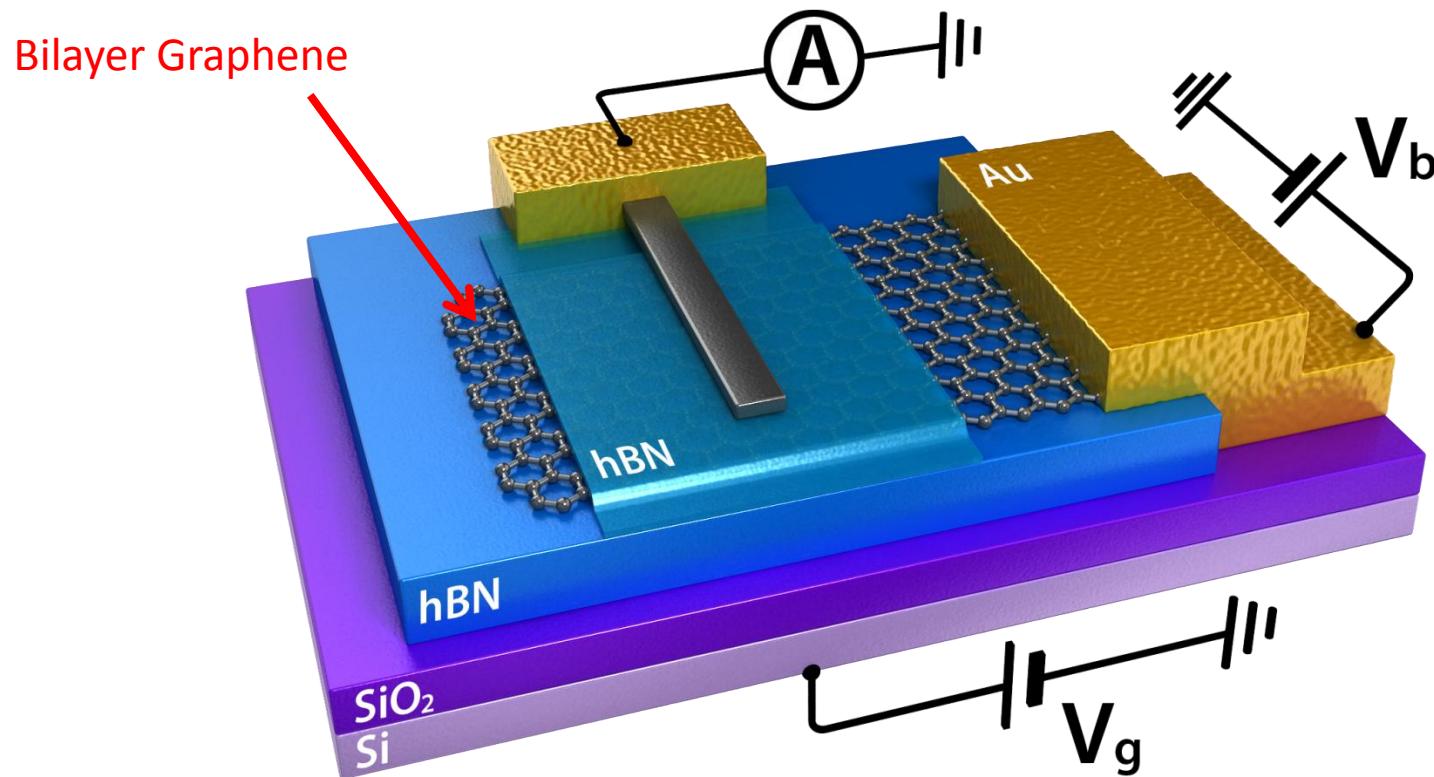
@ hole doping region ($V_g = -50 \text{ V}$)



S. Jung, N. Myoung et al. Nano Lett. **17**, 206-213 (2017)

Tunneling Spectroscopy with h-BN as Insulator

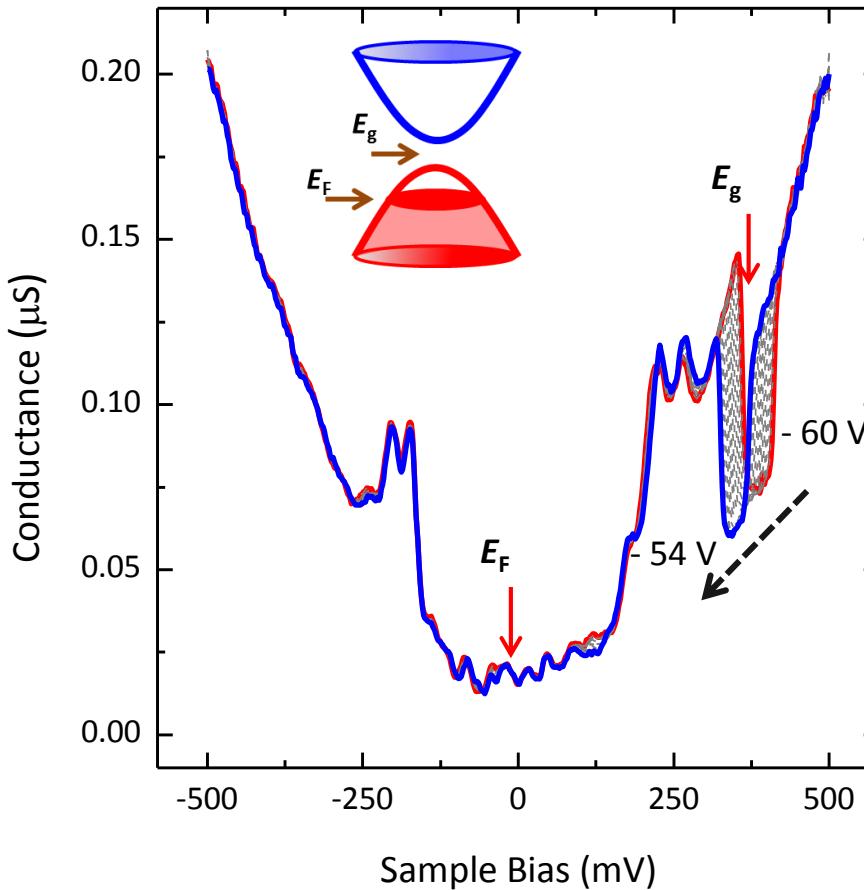
KRISs



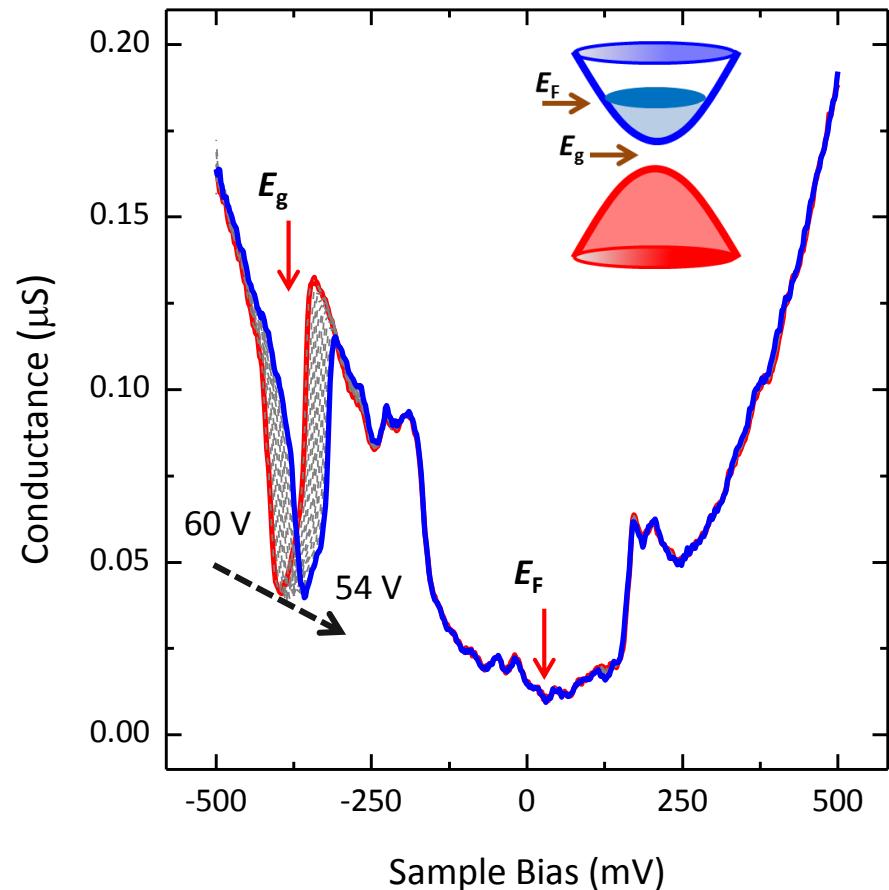
Tunneling Spectroscopy of Bilayer Graphene Device

KRISs

@ hole doping region ($-60 \text{ V} < V_g < -54 \text{ V}$)

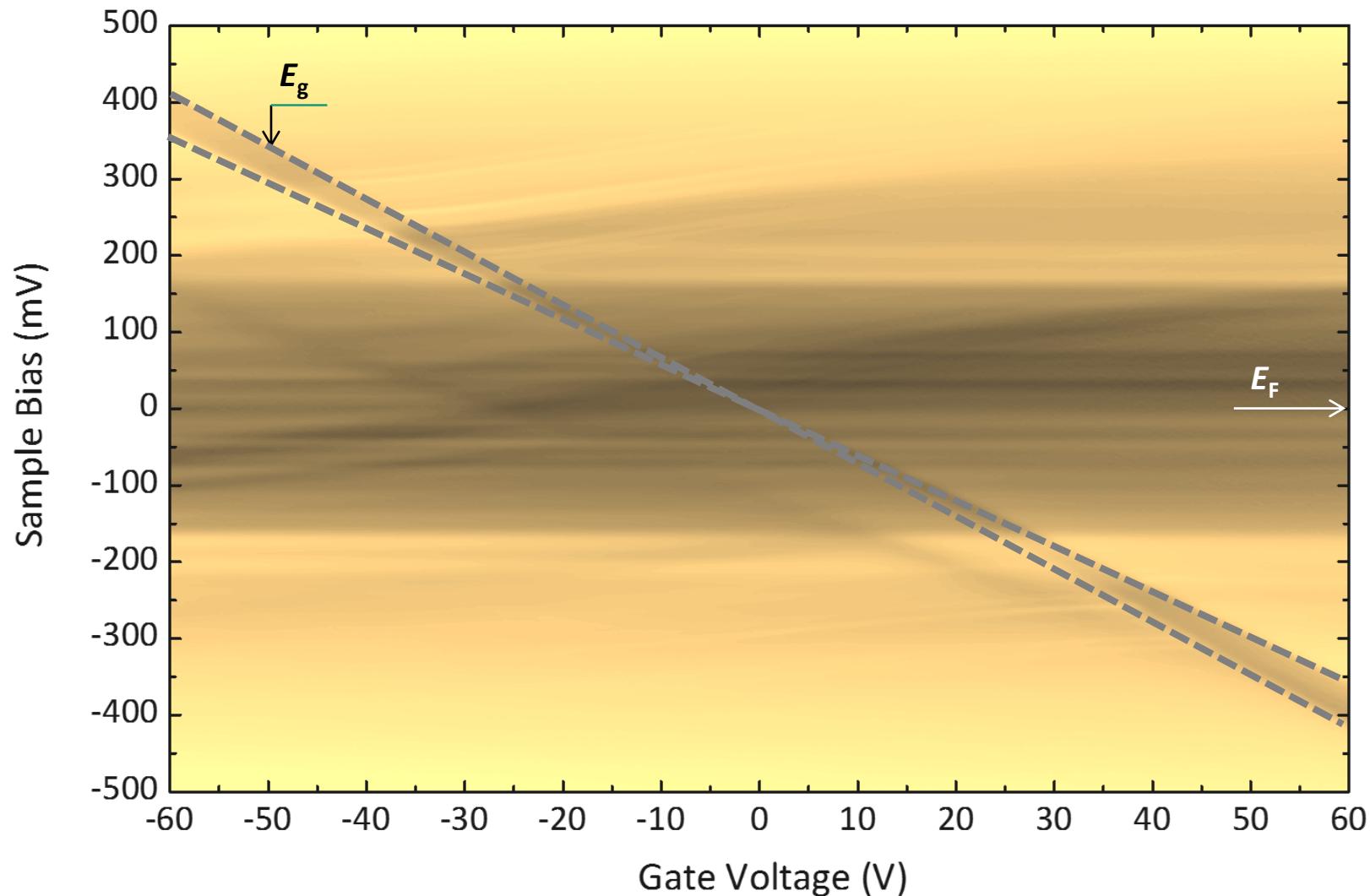


@ electron doping region ($54 \text{ V} < V_g < 60 \text{ V}$)

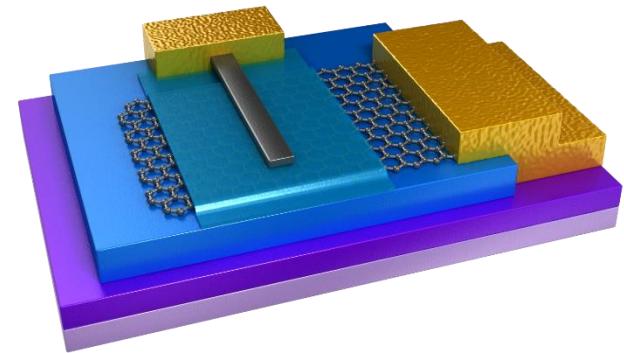
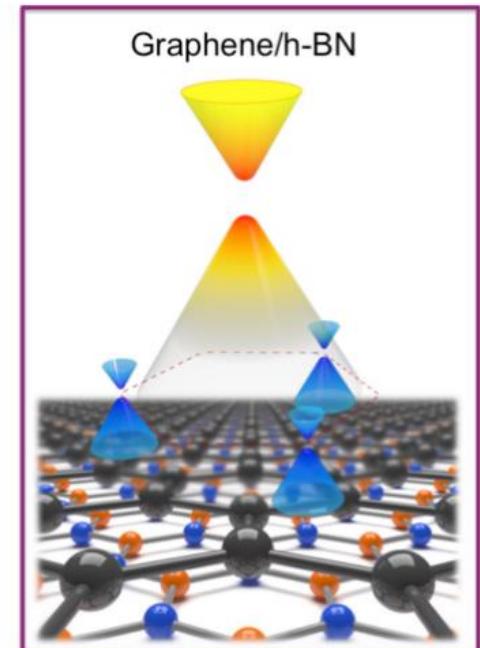
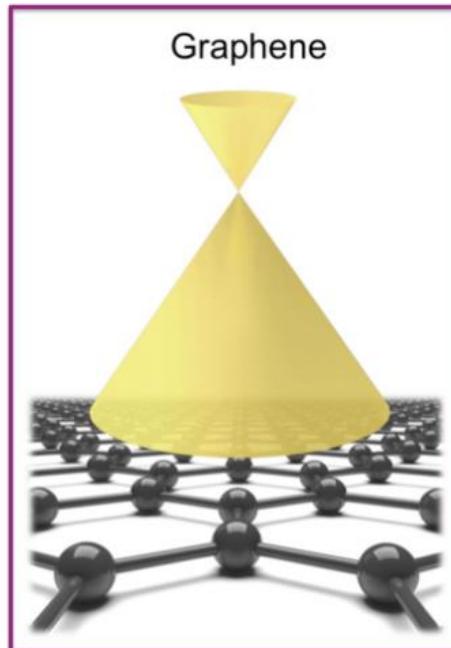
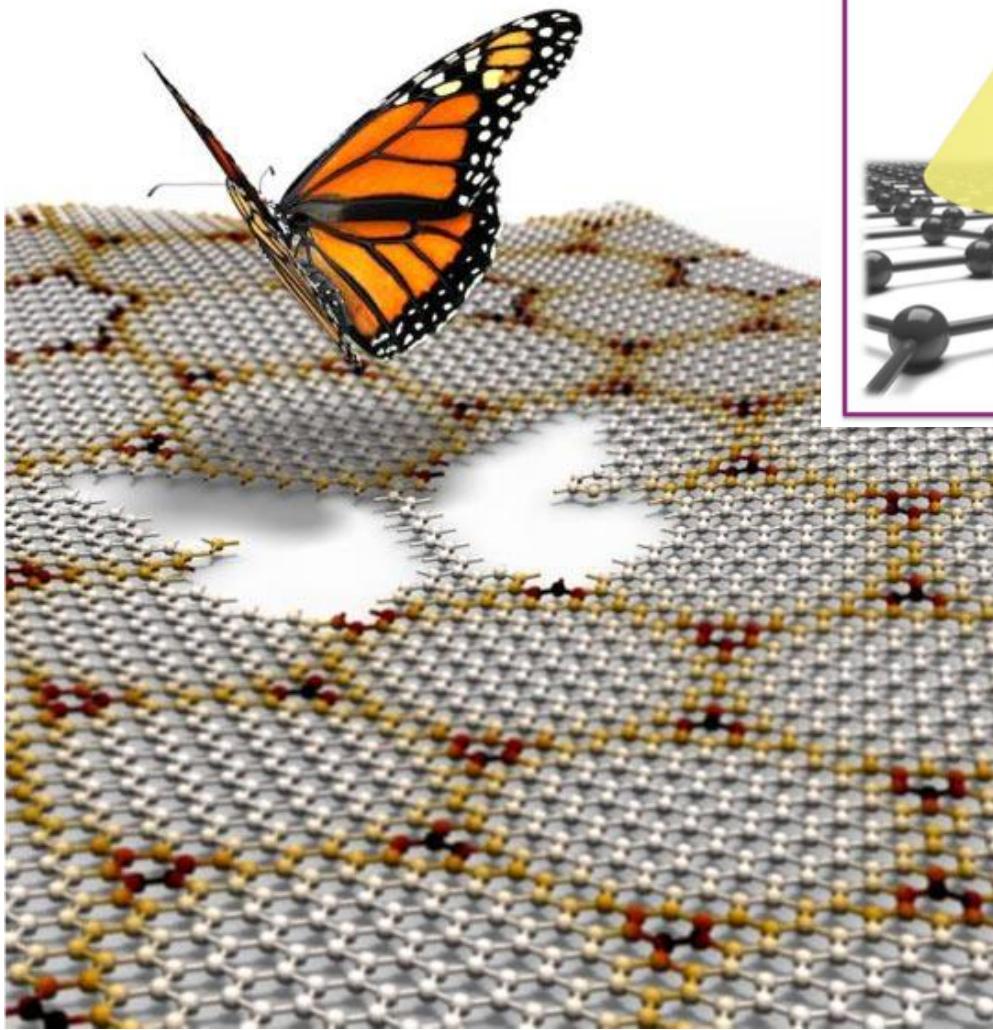


Gate Mapping of Bilayer Graphene Device

KRISs



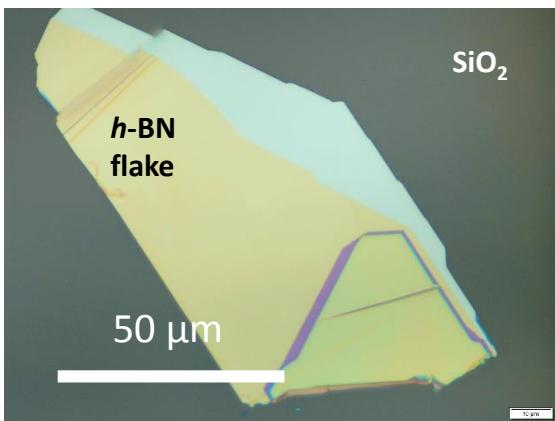
S. Jung, N. Myoung *et al.* Nano Lett. **17**, 206-213 (2017)



Fabricating Graphene-*h*-BN Tunneling Devices

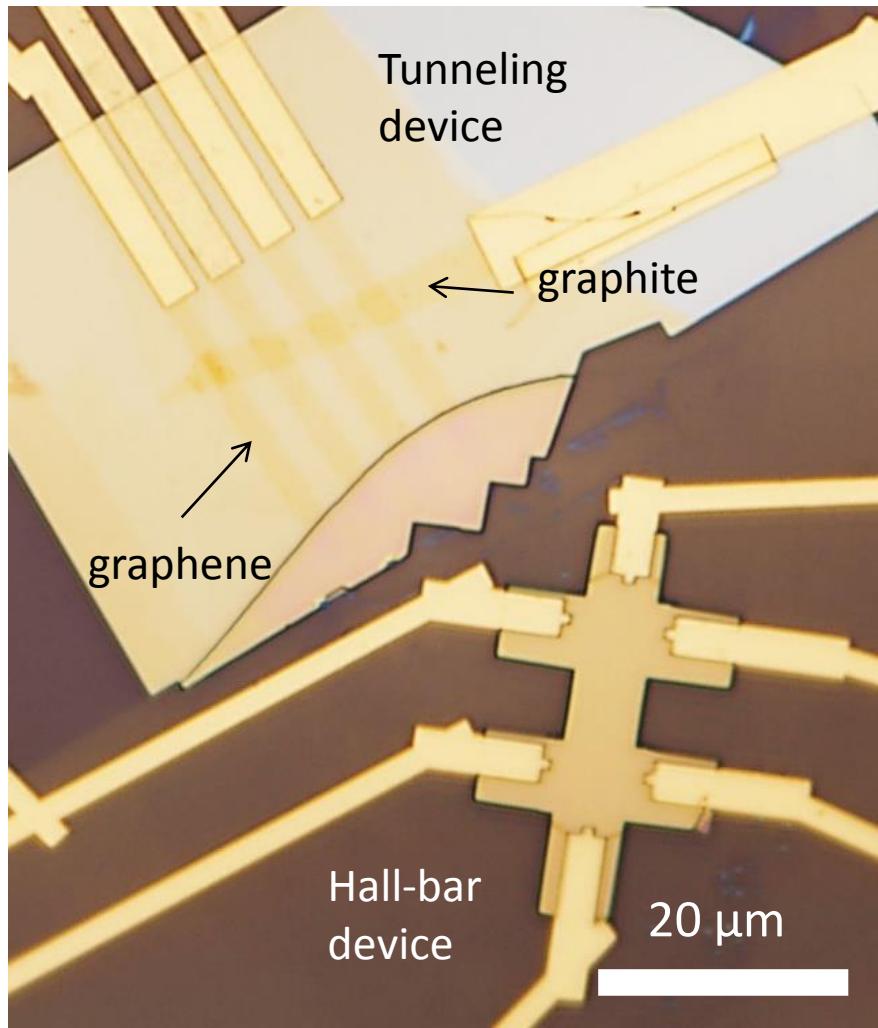
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h-BN/SiO₂

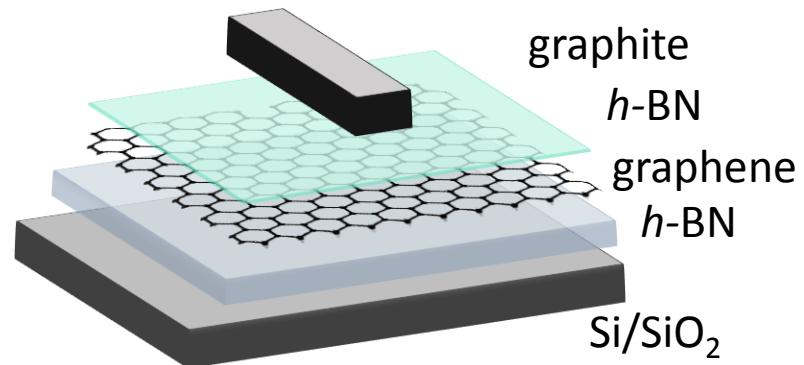


Fabricating Graphene-*h*-BN Tunneling Devices

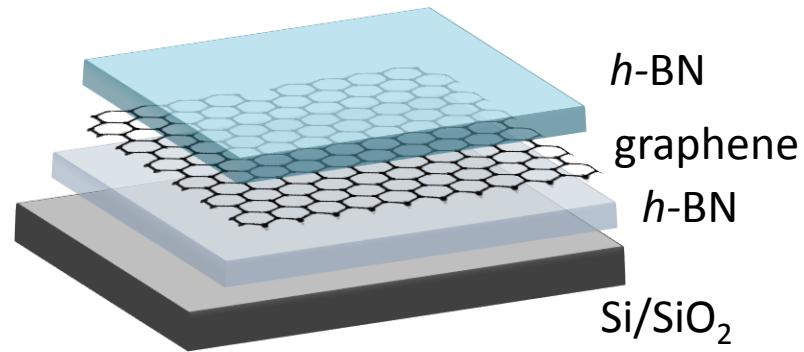
KRISs



Tunneling device

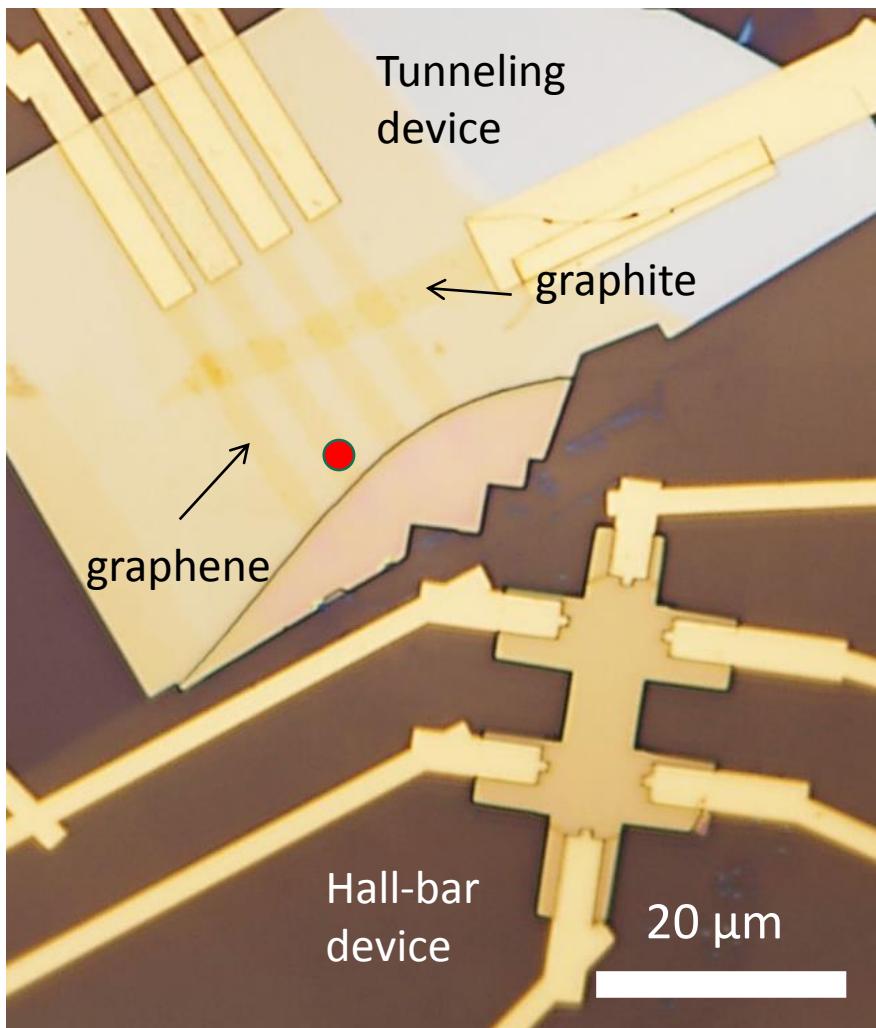


Edge-contact Hall-bar device

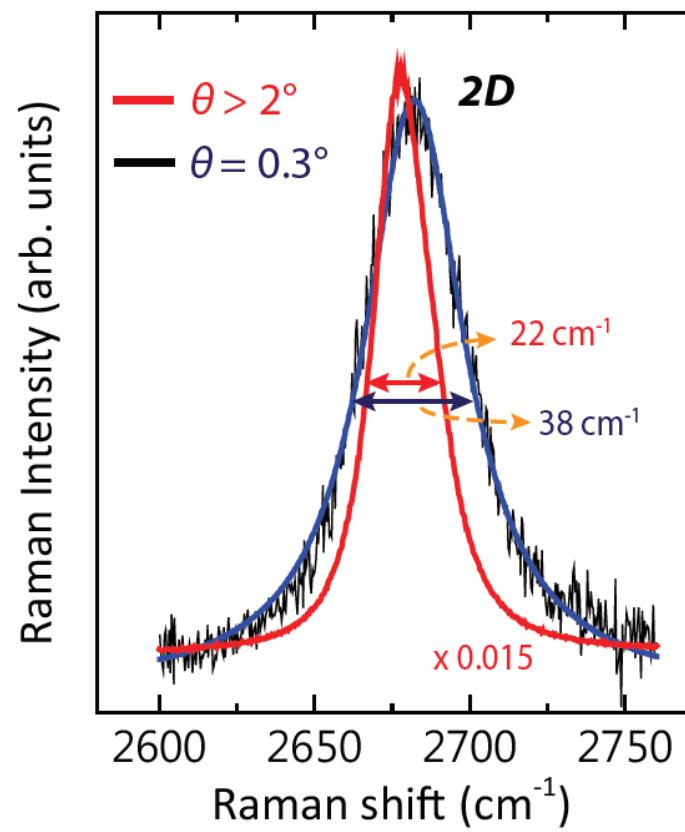


Basic Parameters for Graphene Superlattice

KRISs

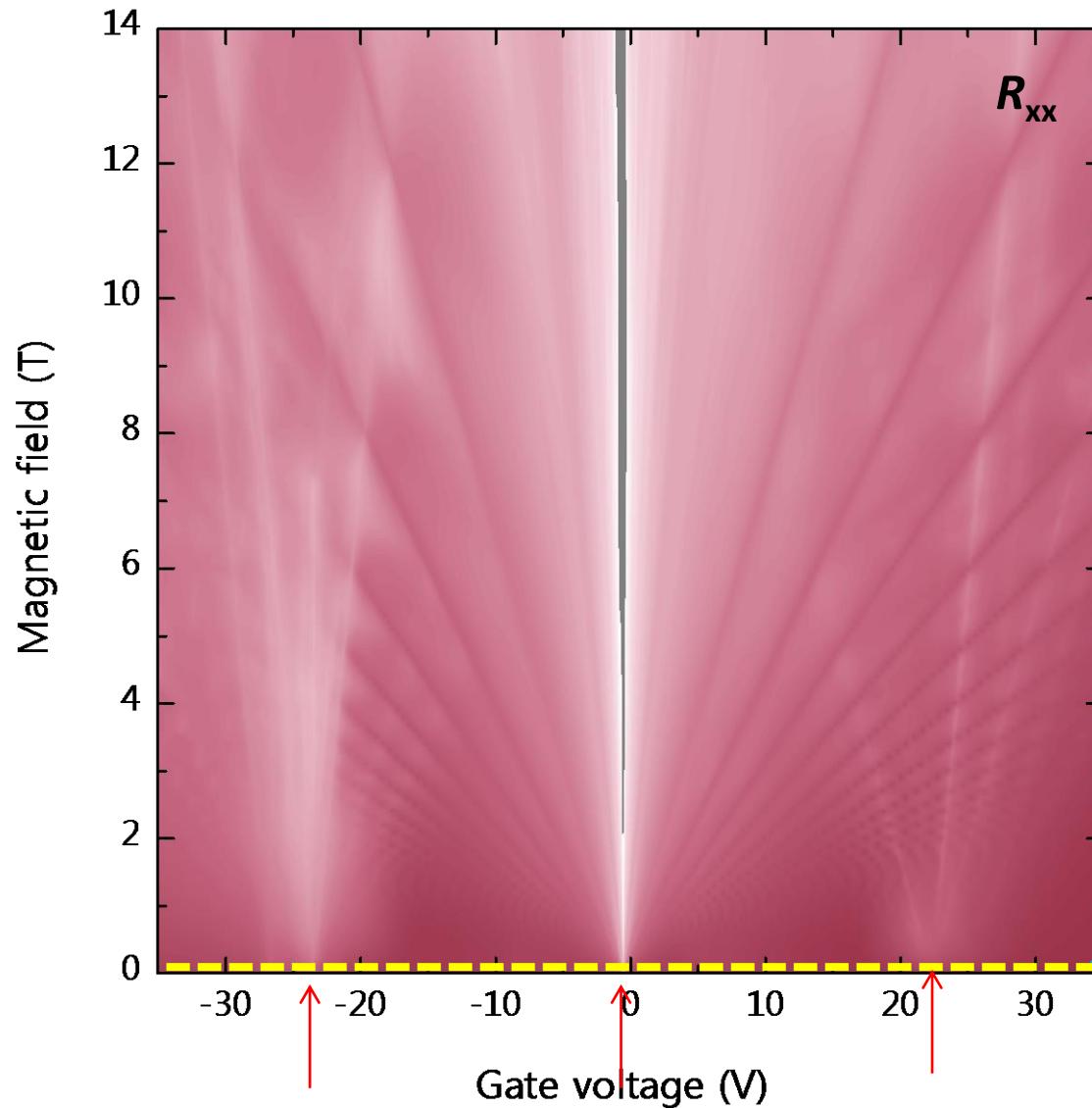


Twist angle (i.e. Moire superlattice length)
from the FWHM width of Raman 2D

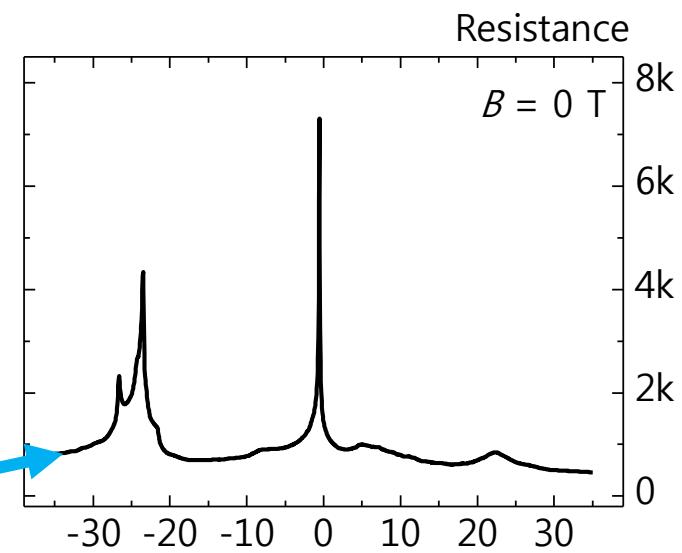


Basic Parameters for Graphene Superlattice

KRISs

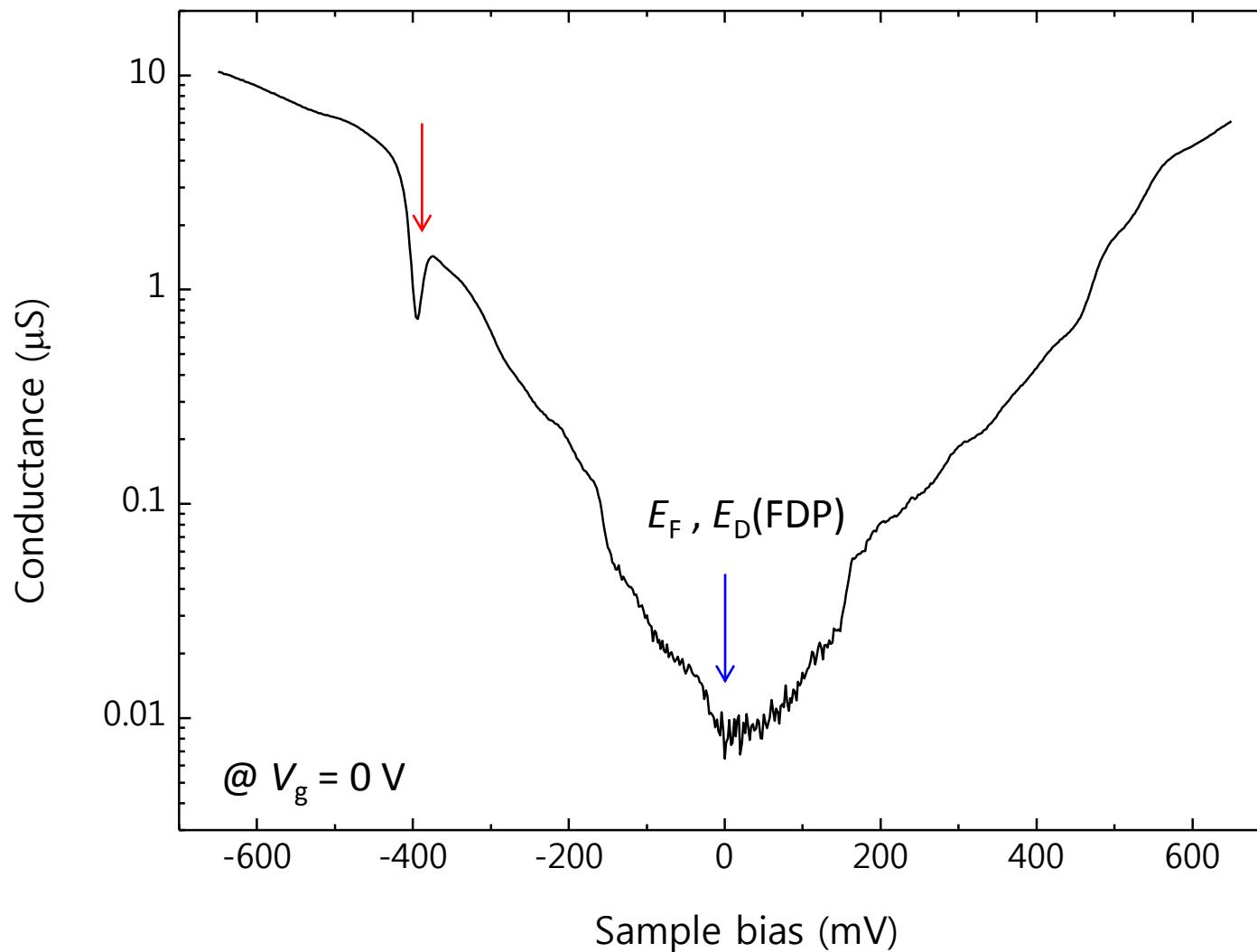


V_g (FDP) = -0.5 V , V_g (SDP) = -23.1 V
density(n) = $2.35 \times 10^{12} \text{ cm}^{-2}$
 E_D @ SDP : 0.18 eV
Superlattice length: 13.4 nm
Twist angle : 0.3°



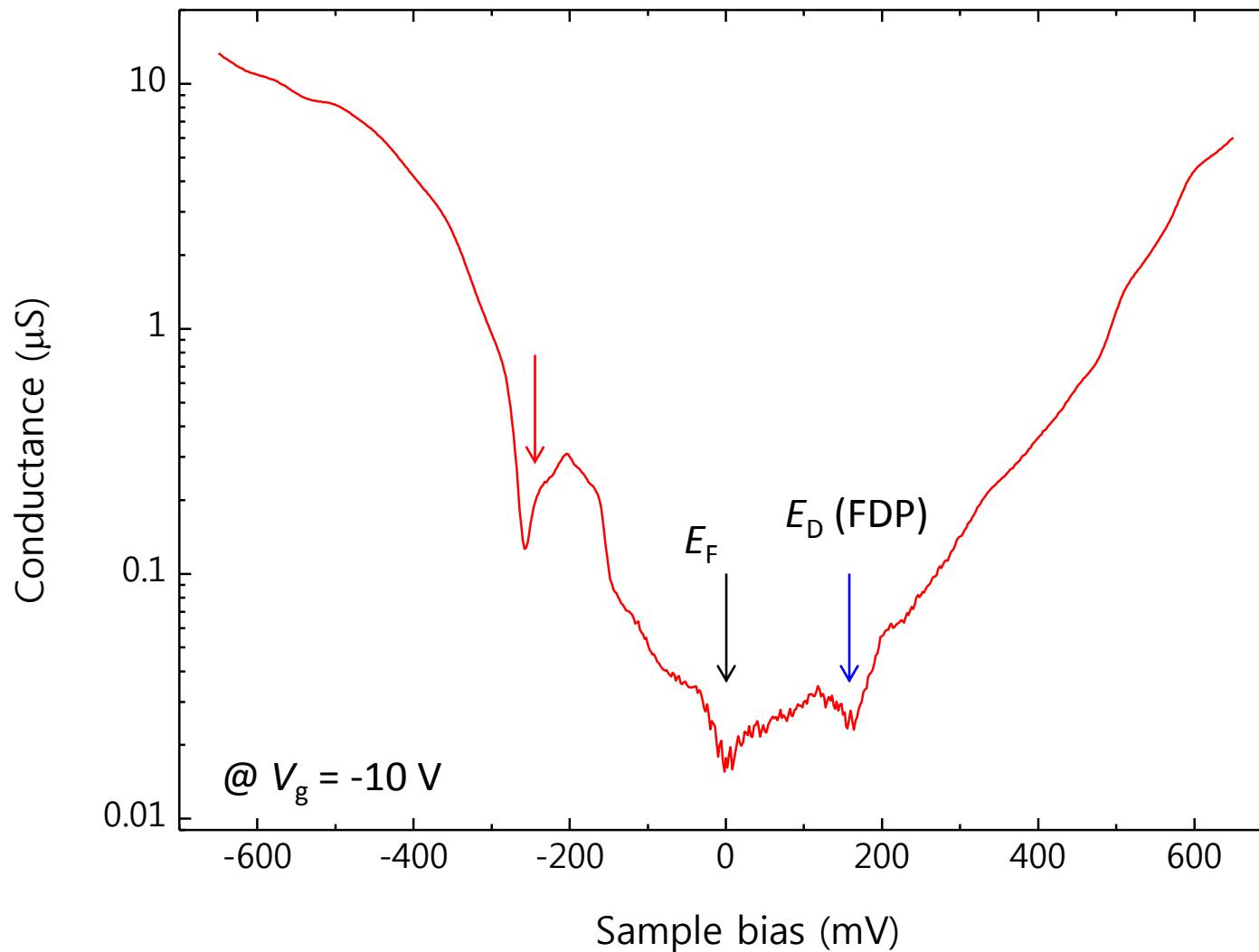
Tunneling Spectra of Graphene-*h*-BN Superlattice

KRISs



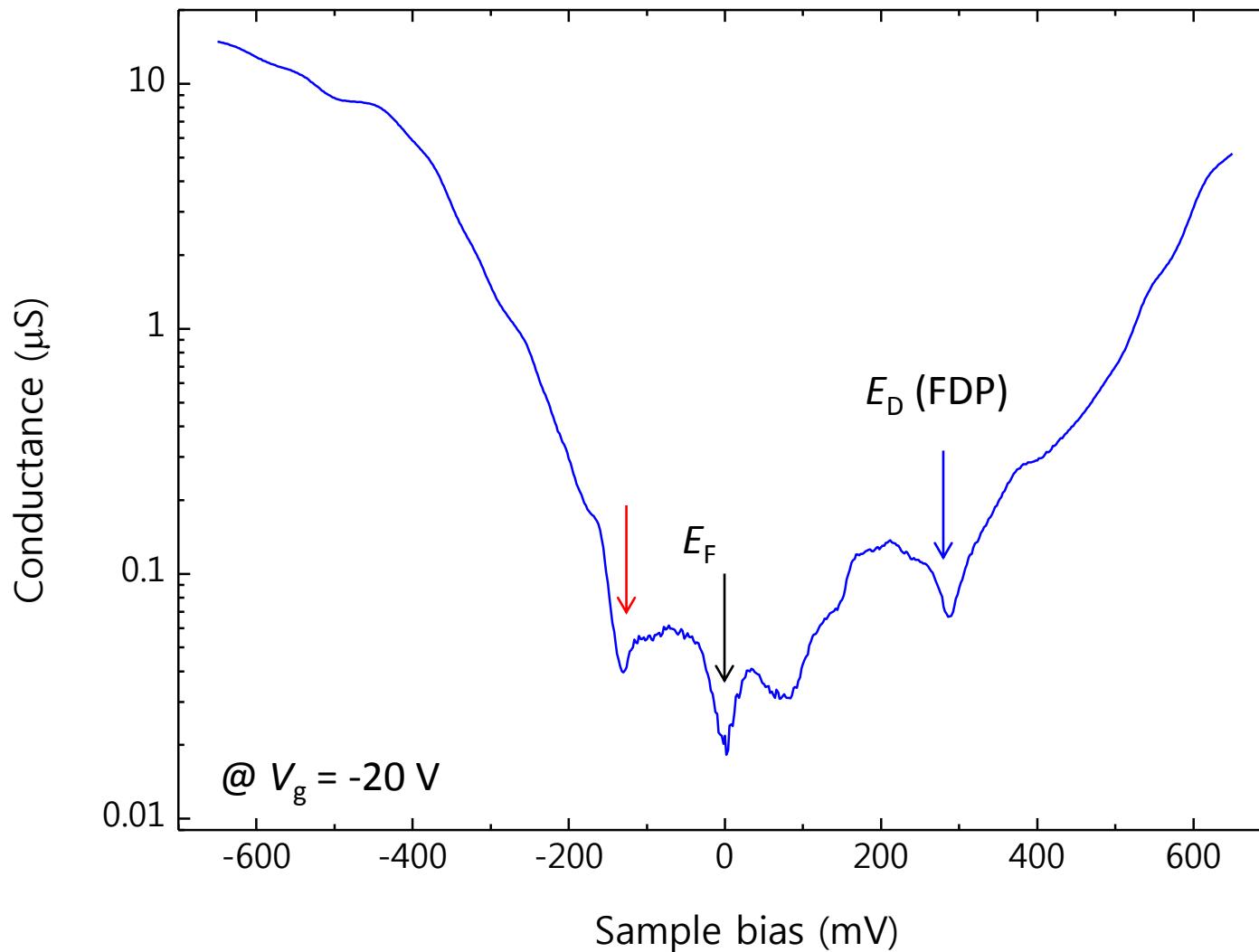
Tunneling Spectra of Graphene-*h*-BN Superlattice

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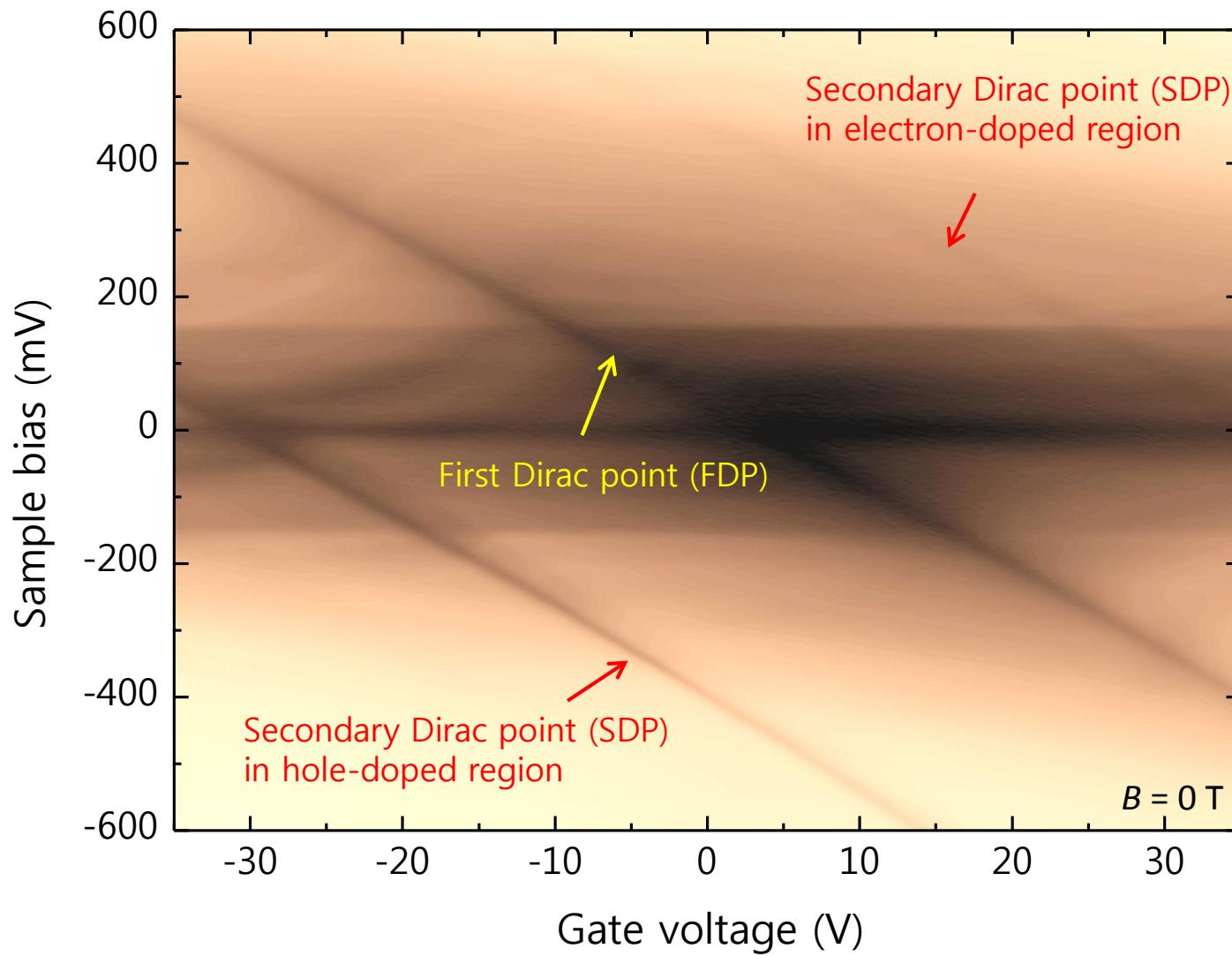
Tunneling Spectra of Graphene-*h*-BN Superlattice

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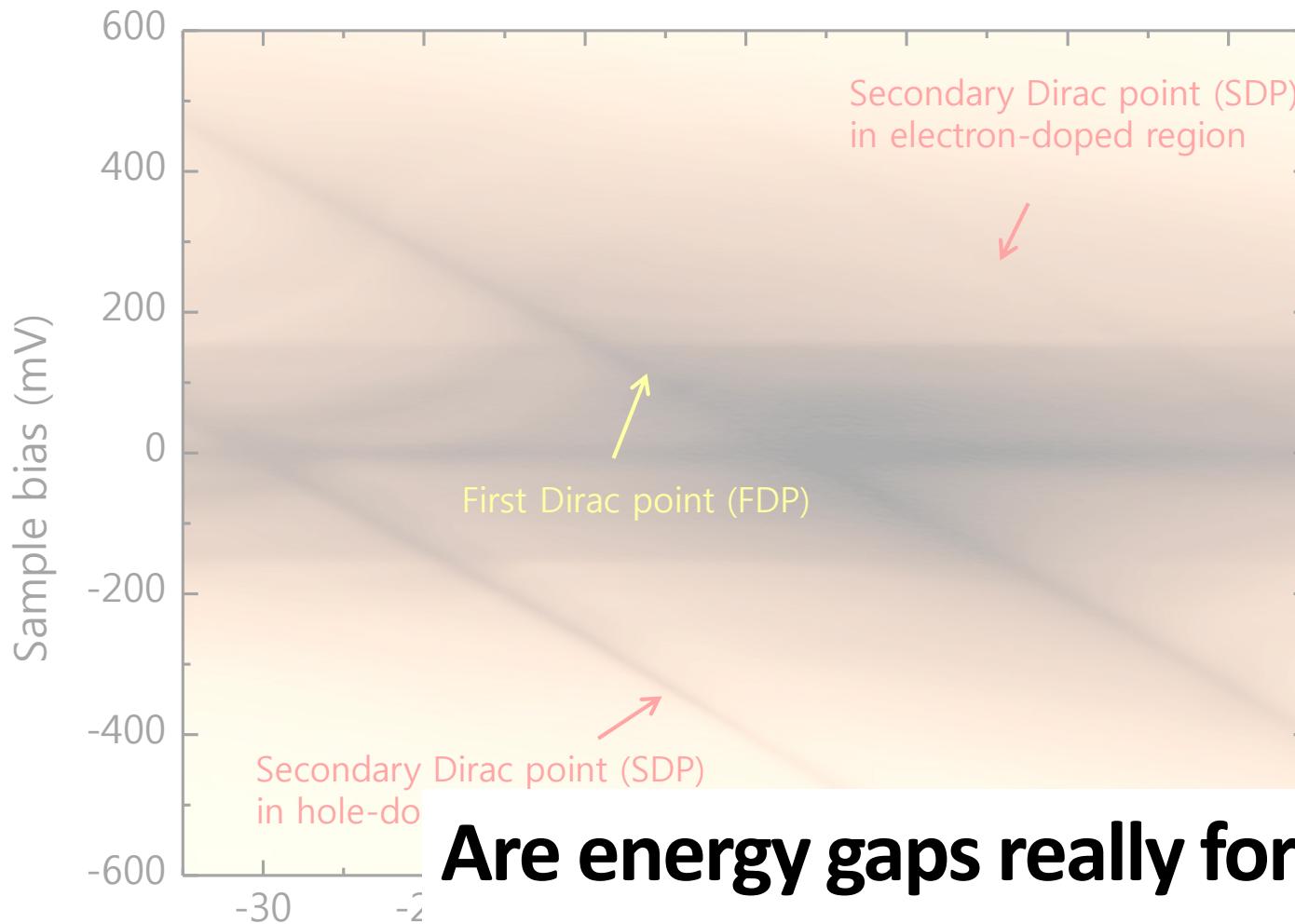
Tunneling Spectra of Graphene-*h*-BN Superlattice

KRISs



Tunneling Spectra of Graphene-*h*-BN Superlattice

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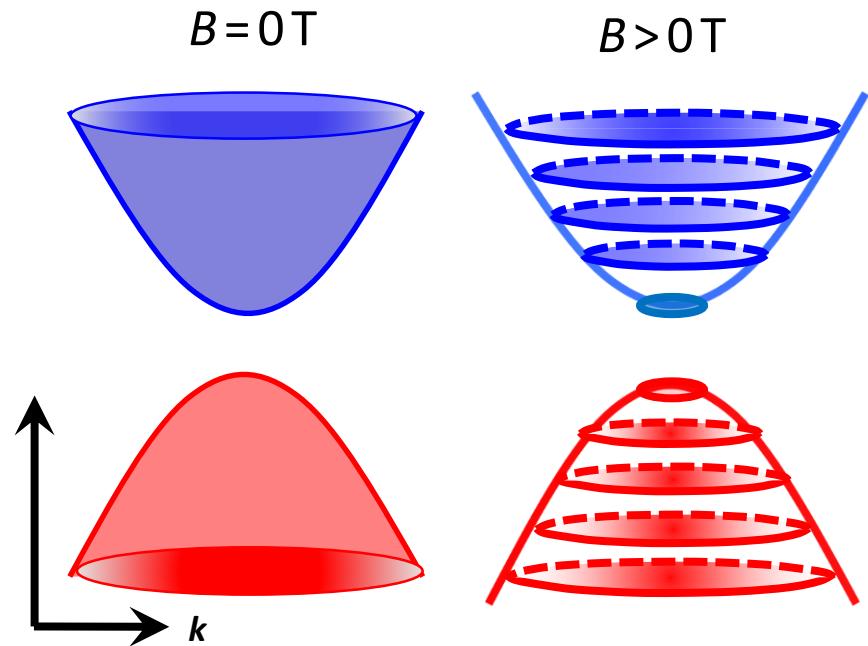


**Are energy gaps really formed
at both the DPs ?**

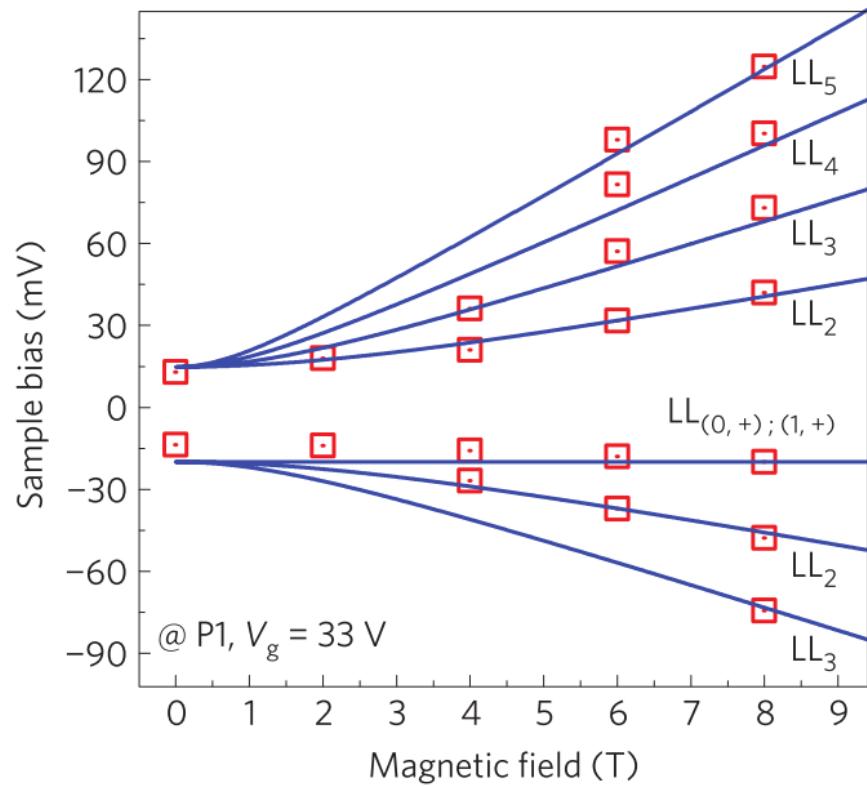
Landau Level Spectroscopy for Energy-gap Analysis

KRISs

Bilayer graphene with an energy gap

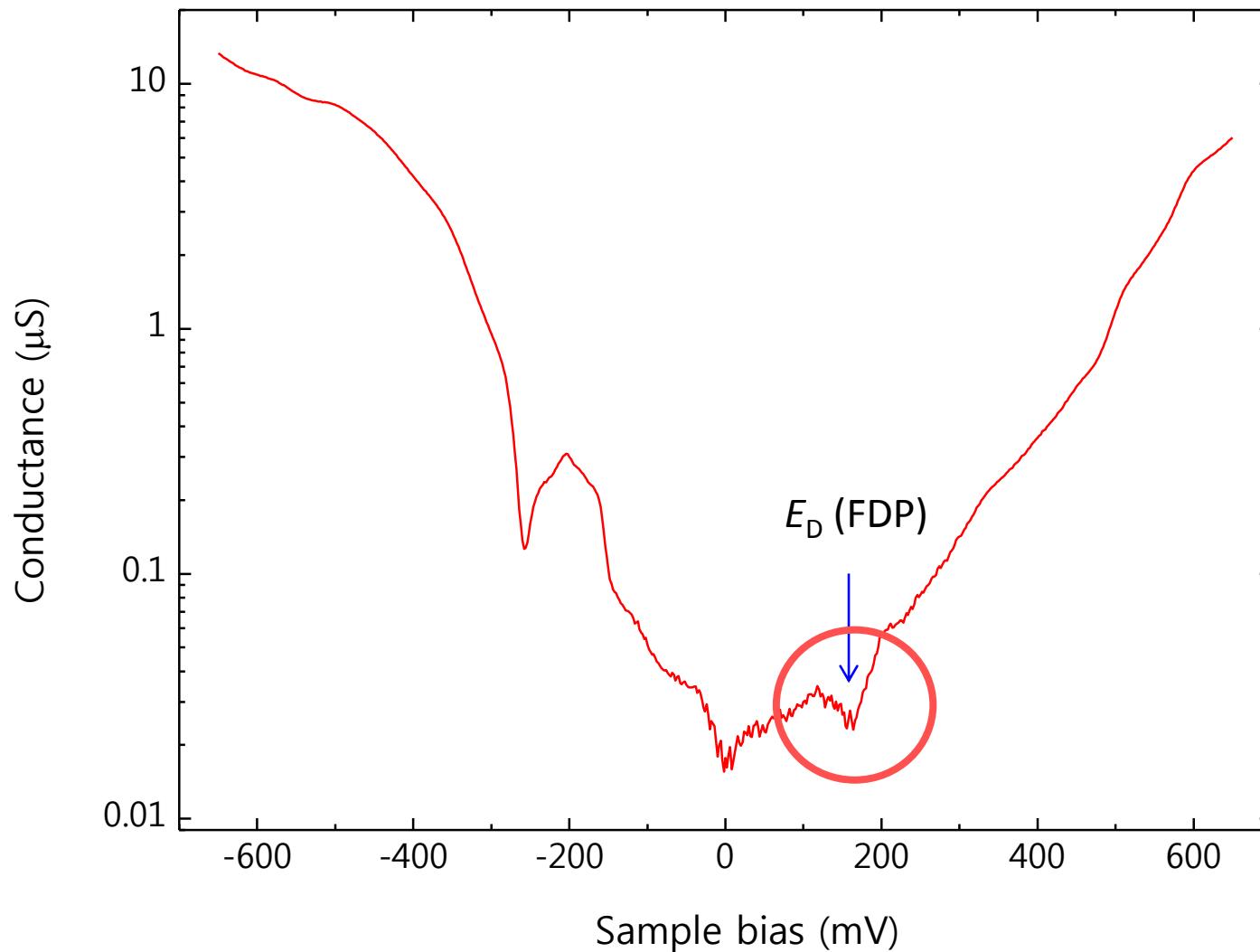


Landau-level spectroscopy



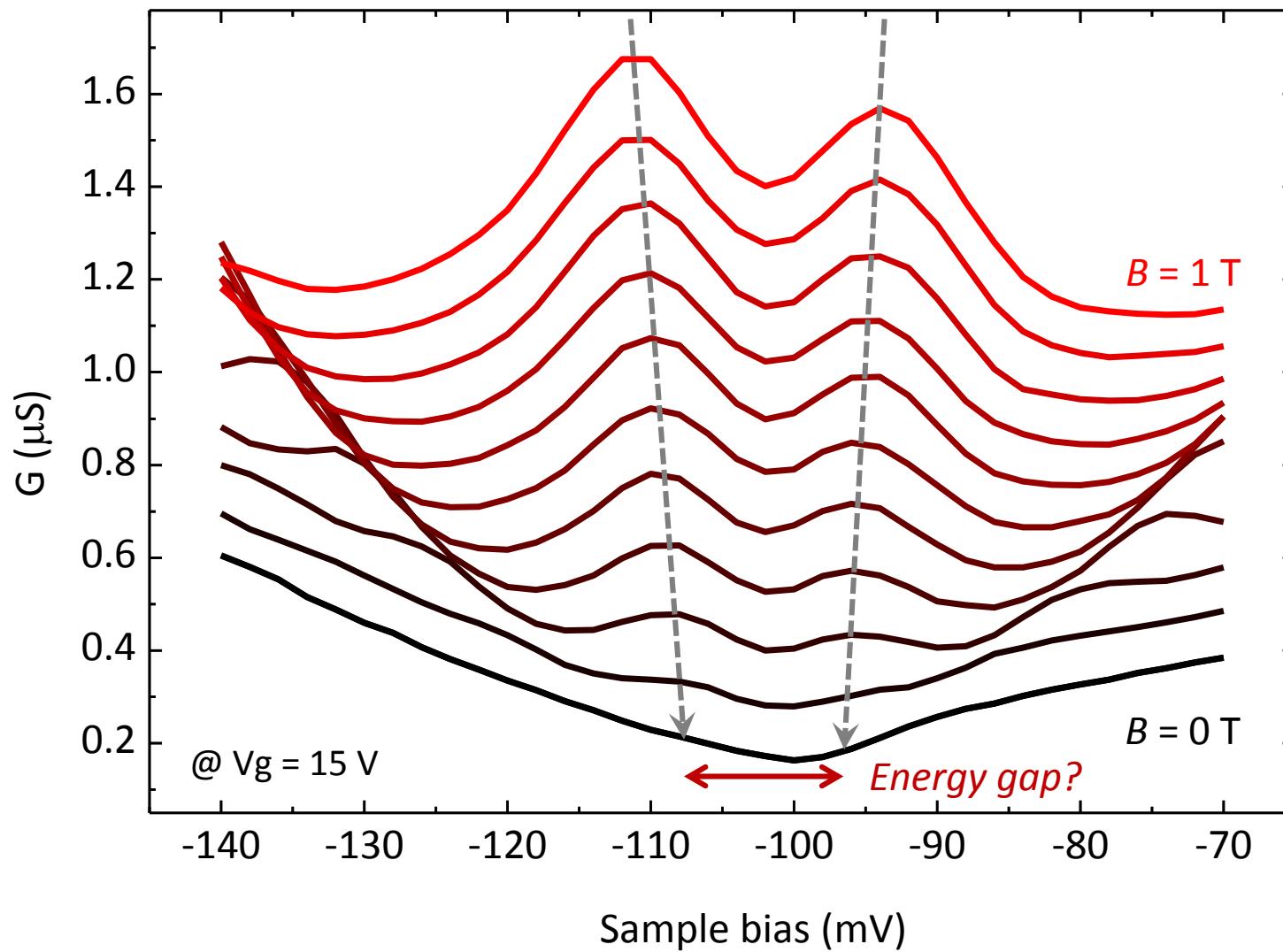
Tunneling Spectra of Graphene-*h*-BN Superlattice

KRISs



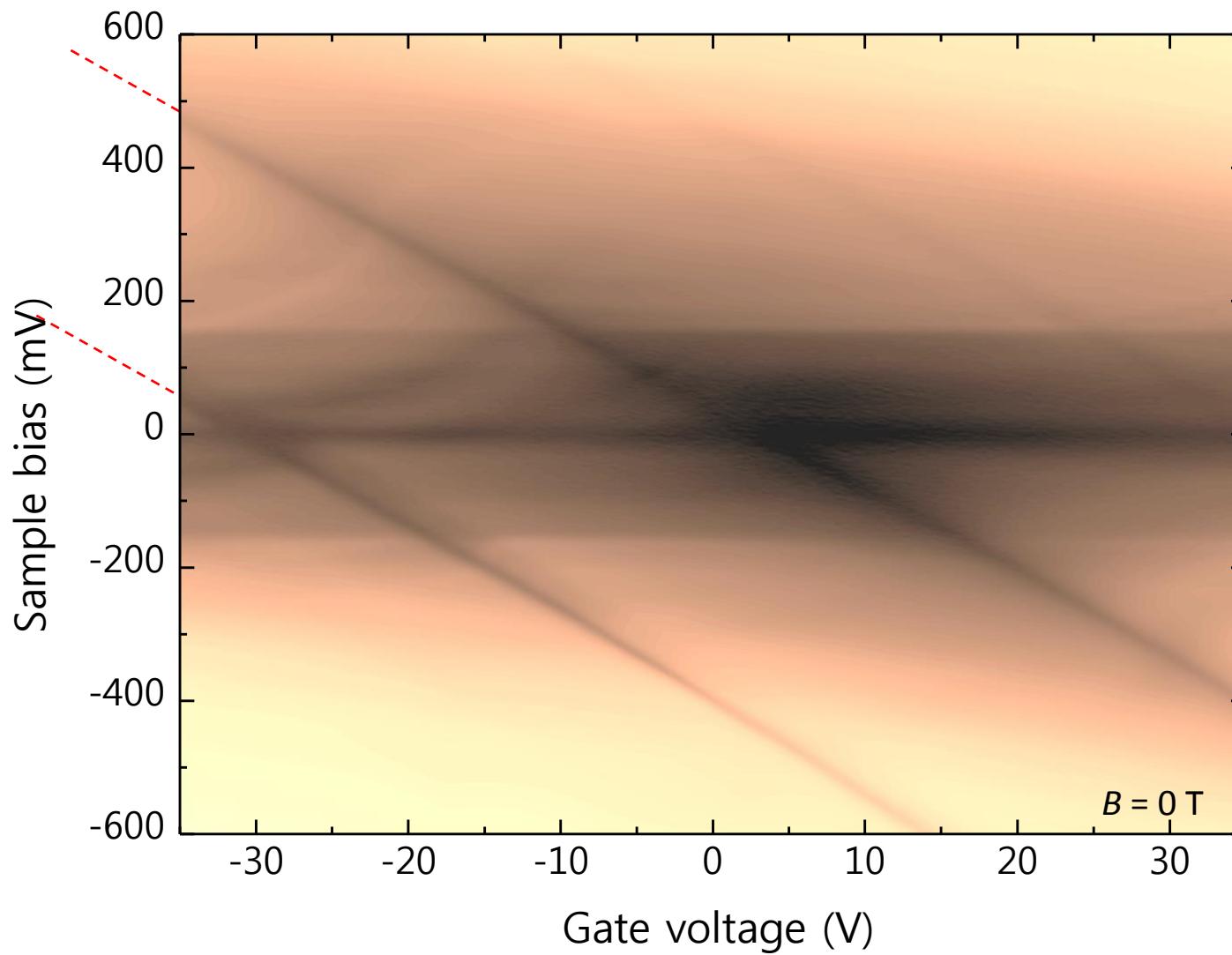
Tunneling Spectra of Graphene-*h*-BN Superlattice

KRISs



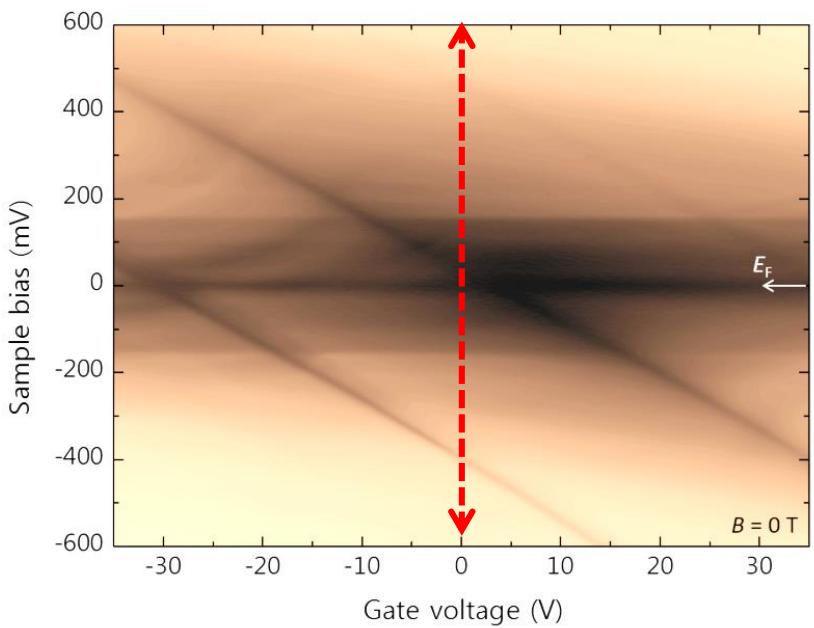
Landau Level Spectroscopy for Gap Analysis

KRISs



Landau Level Spectroscopy for Gap Analysis

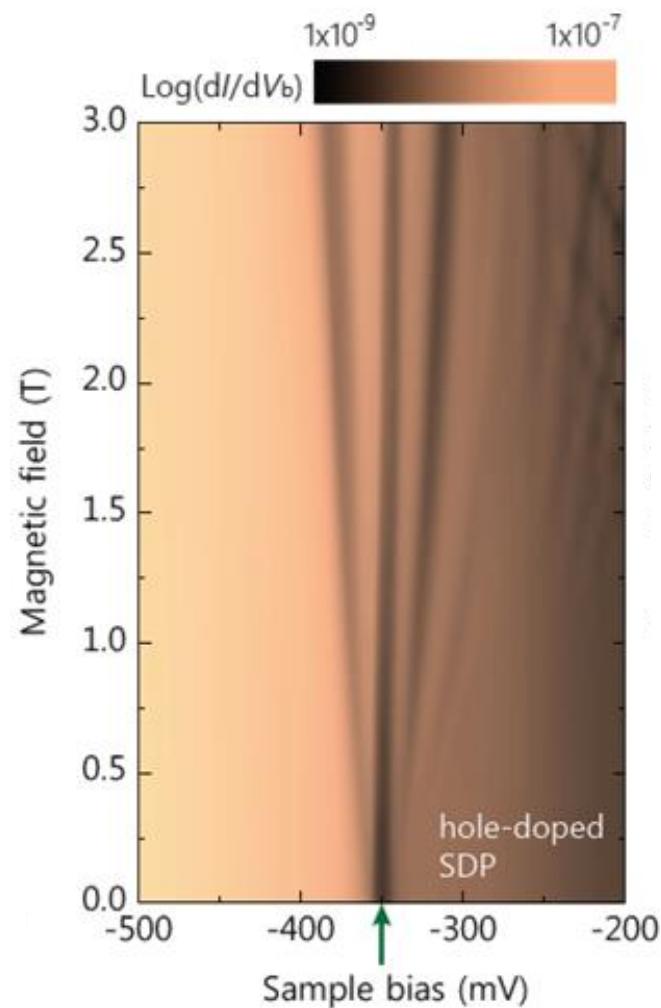
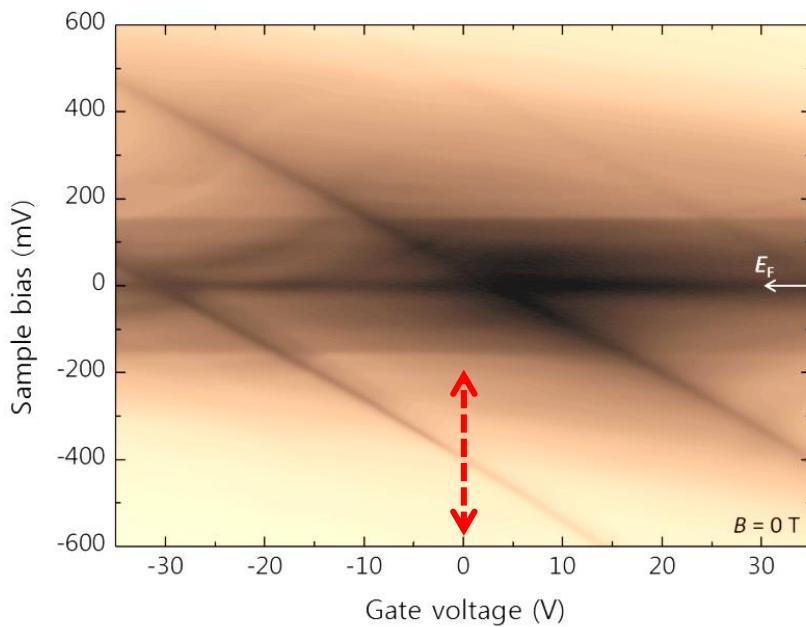
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Landau Level Spectroscopy for Gap Analysis

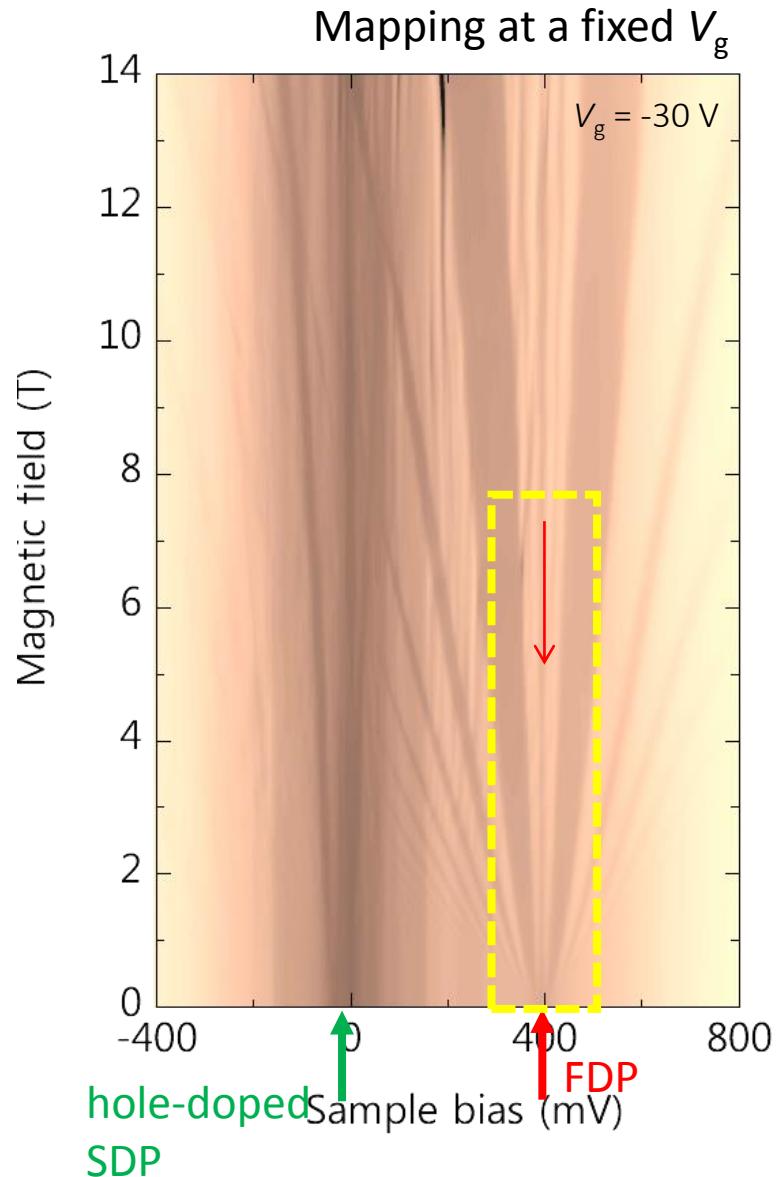
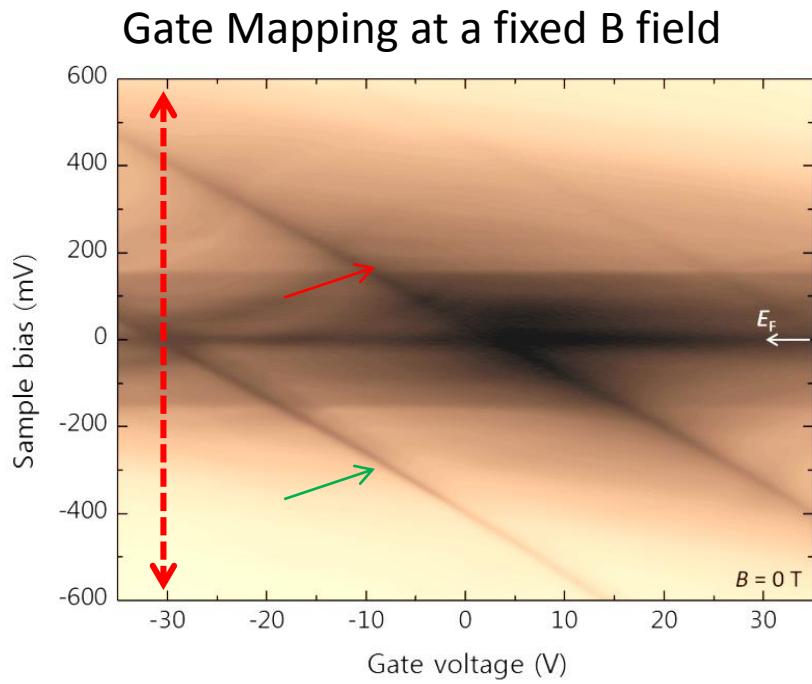
KRISs

Energy gap formed at the 2nd Dirac point
of graphene-*h*-BN superlattice
in hole-doped region



Landau Level Spectroscopy for Gap Analysis

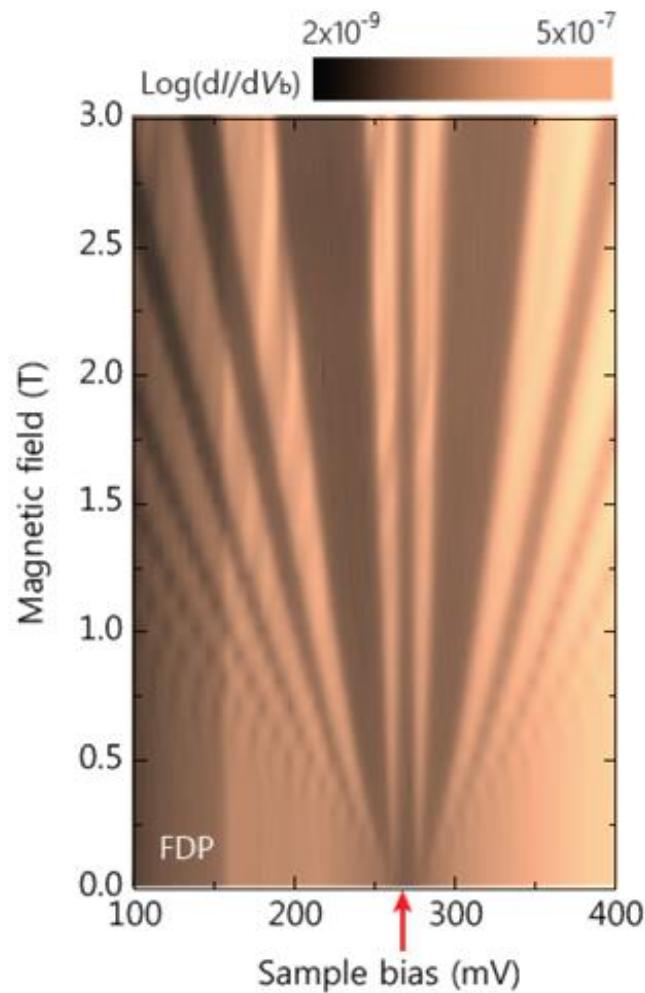
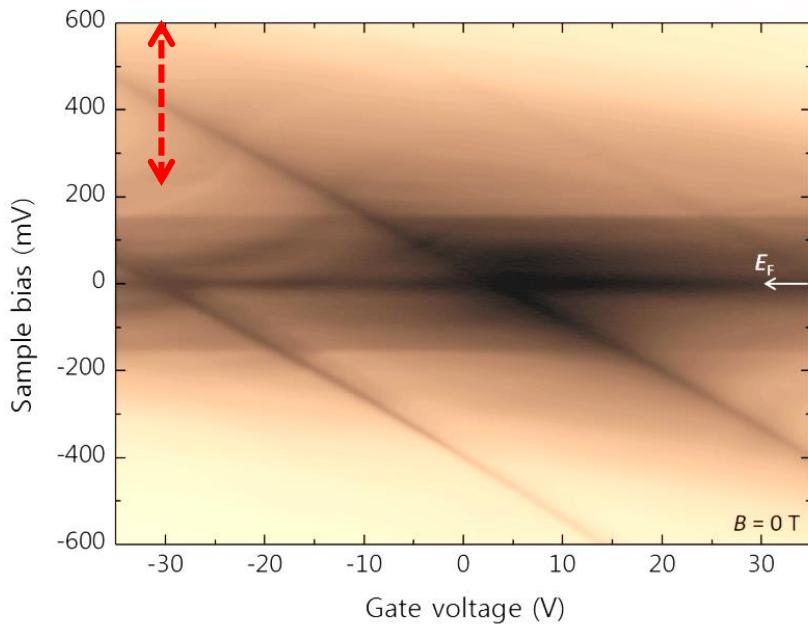
KRISs



Landau Level Spectroscopy for Gap Analysis

KRISs

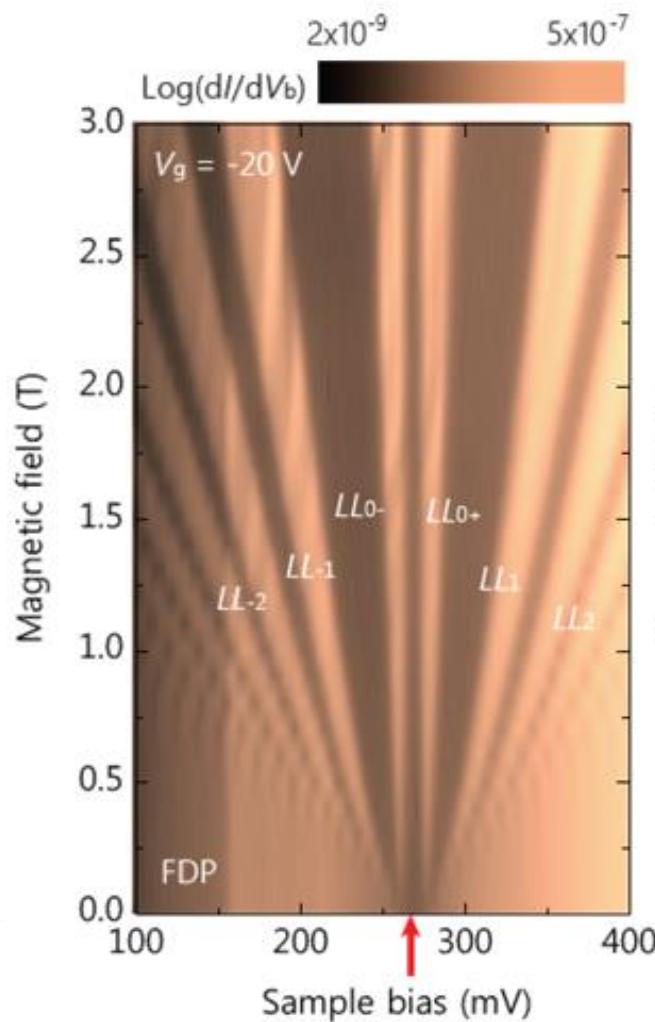
Energy gap formed at the 1st Dirac point
of graphene-*h*-BN superlattice



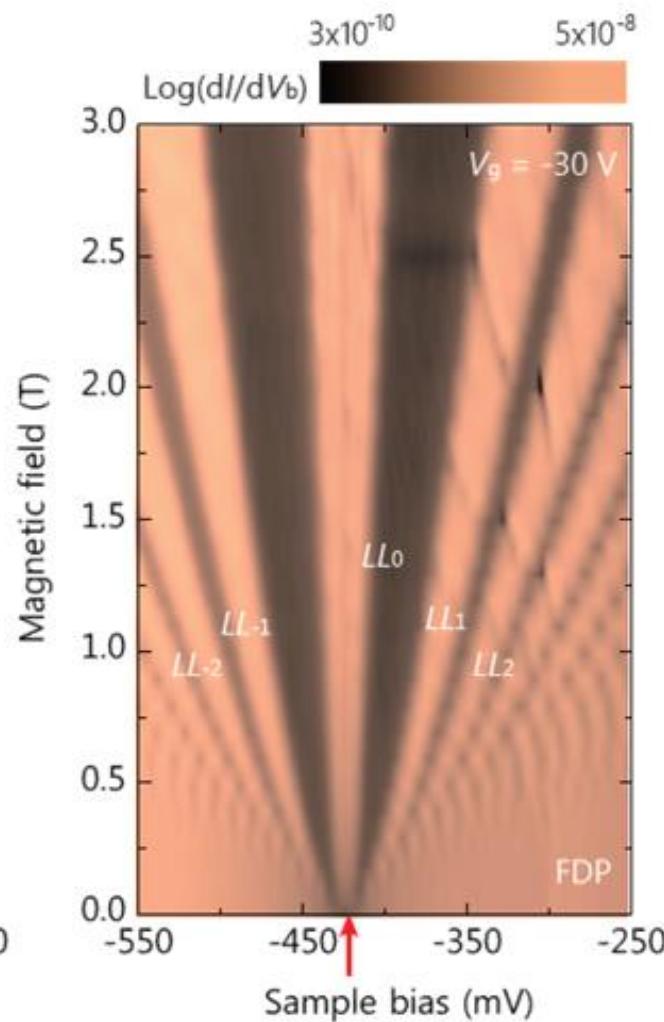
Landau Level Spectroscopy for Gap Analysis

KRISs

Energy gap at the 1st Dirac point



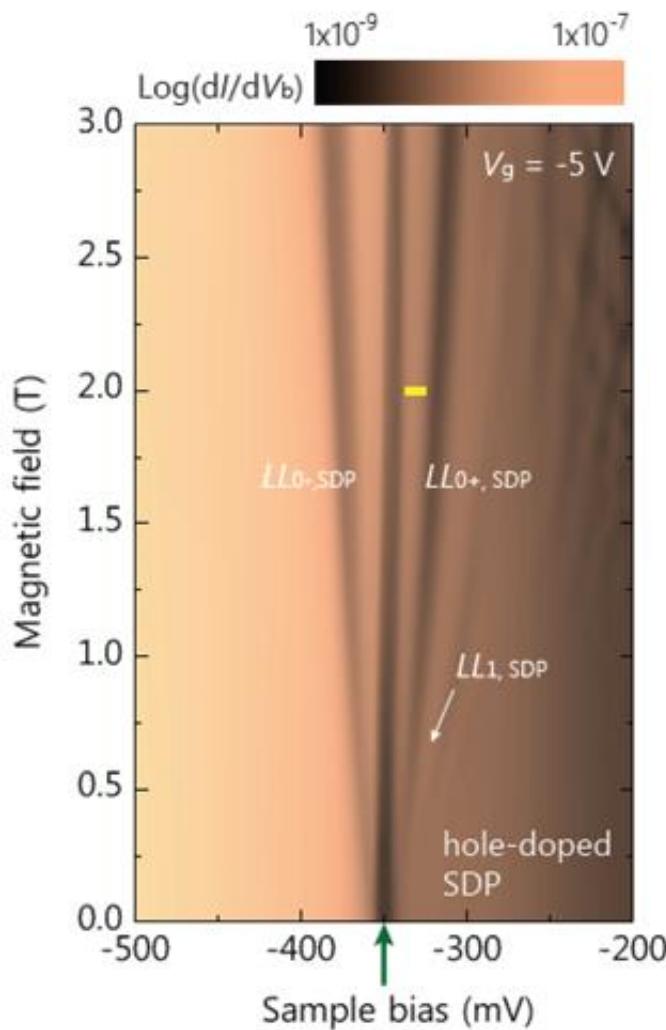
Dirac point from misaligned graphene-*h*-BN device



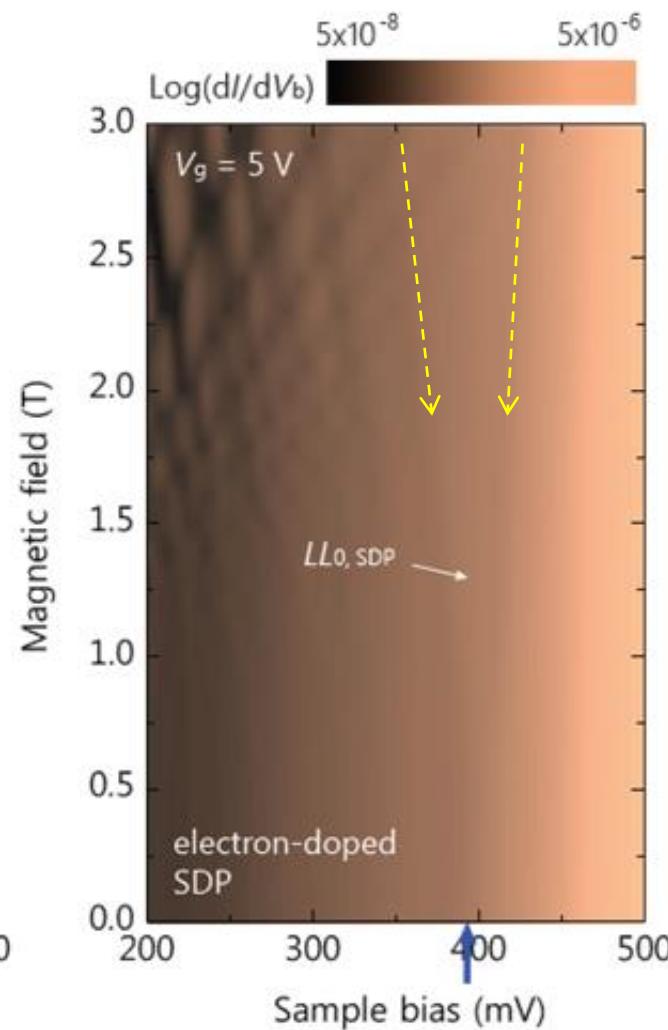
Landau Level Spectroscopy for Gap Analysis

KRISs

2nd Dirac point in hole-doped region



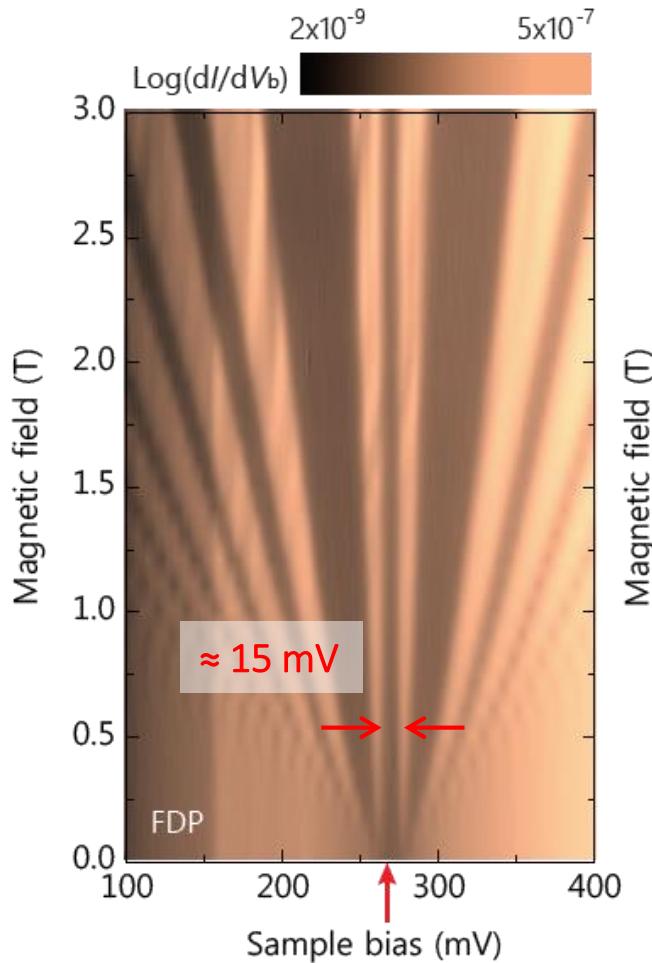
2nd Dirac point in electron-doped region



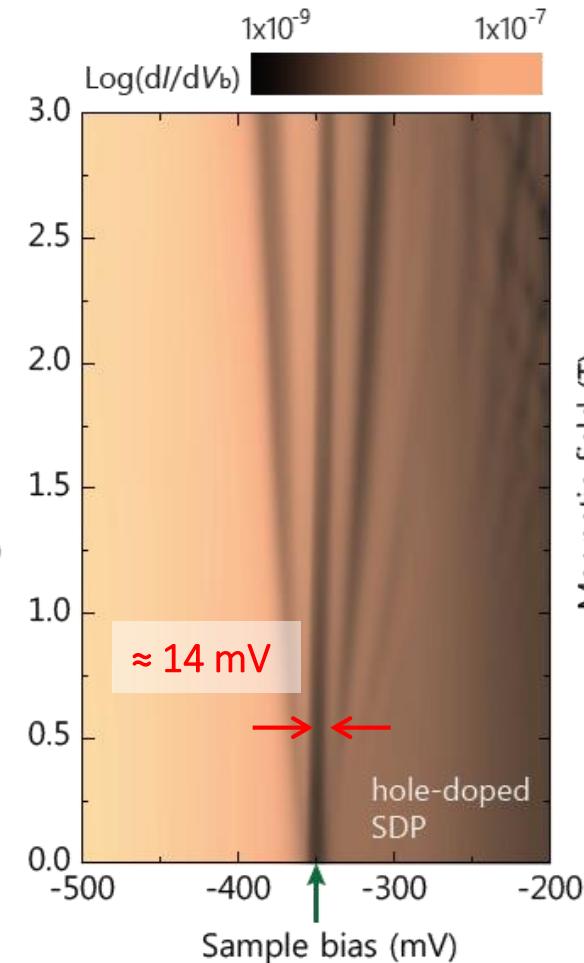
Landau Level Spectroscopy for Gap Analysis

KRISs

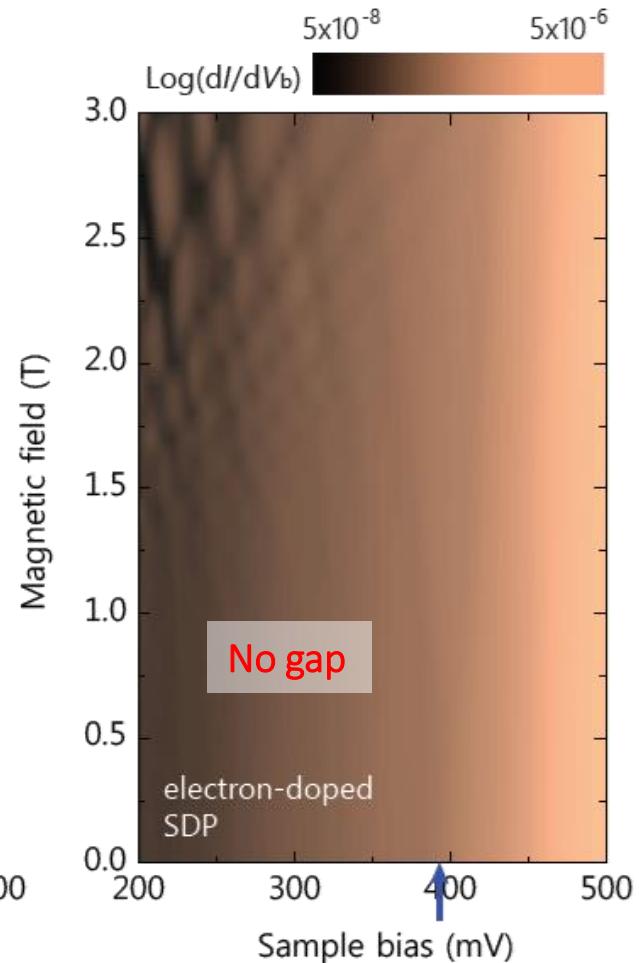
Energy gap at the 1st DP



2nd DP in hole-doped region



2nd DP in electron-doped region



Summary / Ongoing Efforts



Developed experimental platforms for high-quality graphene devices

: hybrid devices with h-BN, dry transfer technique

Investigate novel quantum phenomena in low-dimensional systems

Tunneling spectroscopies for low-dimensional systems under various physical conditions

: Carbon nanotubes , Transition Metal Dichalcogenide (TMDC)

: tunneling + optical, thermal, mechanical knobs varying T , B , P and others

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Thank you for your attention